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(54) Title: ORGANIC SEMICONDUCTOR MATERIAL

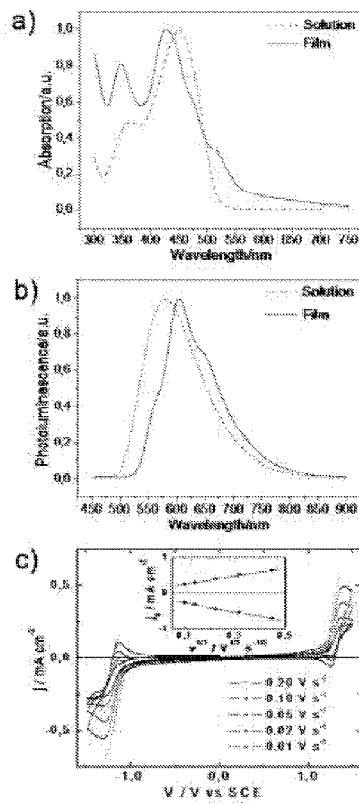


Fig.1

(57) Abstract: The present invention relates to a novel compounds useful as organic semiconductor material, and semiconductor devices containing said organic semiconductor material.



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## ORGANIC SEMICONDUCTOR MATERIAL

The present invention relates to a novel n-type organic semiconductor material, and semiconductor devices containing said n-type organic semiconductor material.

5 It is known that organic semiconductors are materials into which charge can be reversibly introduced by the application of electromagnetic energy or chemical dopants. The electronic conductivity of these materials lies between that of metals and insulators, spanning a broad range of  $10^{-9}$  to  $10^3 \Omega^{-1} \text{ cm}^{-1}$ . As in traditional inorganic semiconductors, organic materials can function either as p-type or n-type. In p-type 10 semiconductors the majority carriers are holes, while in n-type the majority carriers are electrons.

The vast majority of the prior art has focused on the design, synthesis, and structure-property relationships of p-type organic semiconductor materials, including: 15 oligoacenes, fused oligothiophenes, anthradithiophenes, carbazoles, oligophenylenes, and oligofluorenes, some of which have resulted in field-effect transistors with performance superior to amorphous silicon. In contrast, the development of n-type oligomer and polymer semiconductors has lagged behind p-type materials. In fact, compared to the p-type semiconductors, n-type semiconductors are still not fully developed, and the performances are not satisfactory.

20 Organic semiconductors that possess a high electron affinity are however also required, as both p- and n-channel materials are required for efficient logic circuits and organic solar cells. Indeed, n-type organic field-effect transistors are envisioned as key components of organic p-n junctions, bipolar transistors, and complementary integrated circuits leading to flexible, large-area, and low-cost electronic applications.

25 A variety of organic semiconductors have been considered in the art as n-type organic semiconductor materials.

30 Aromatic tetracarboxylic anhydride and their diimide derivatives were reported among the first n-channel materials. Among the materials of this class, perylenetetracarboxylic diimides having fluorinated side chains showed mobilities up to  $0.72 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ , which only slightly decreased upon air exposure. Air stability, packing grain size and morphology of the deposited films as well as electrical performance can

be altered by varying side-chain length, insertion of oxygenated groups and degree of fluorination. However, most of the perylene building blocks, due to the structural rigidity and moderate solubility, do not allow readily structural changes limiting the volume of materials accessible.

5 Other classes of n-type organic materials have been described such as cyanovinyl oligomers, fullerenes.

J.Am.Chem.Soc. 2009, 131, 16616-16617 describes ambipolar charge transport properties of diketopyrrolopyrrole-copolymers.

10 A benzothiadiazole-diketopyrrolopyrrole copolymer described in Mater. 2010, 22, 47, 5409-5413, shows high and balanced hole- and electron mobilities of  $0.35\text{ cm}^2\text{V}^{-1}\text{s}^{-1}$  and  $0.40\text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ , respectively. Larger electron mobilities values up to  $0.85\text{ cm}^2\text{V}^{-1}\text{s}^{-1}$  were achieved in air for electron-only transporting n-type polymer, called poly{[N,N9-bis(2-octyldodecyl)-naphthalene-1,4,5,8-bis(dicarboximide)-2,6-diyl]- alt - 5,59-(2,29-bithiophene)}, (Polyera ActivInk N2200), in a staggered top gate 15 configuration.

15 N-type semiconductor materials consisting of oligothiophenes bearing fluorinated side groups have been also described in J. Am. Chem. Soc. 2005, 127, 1348 and Angew. Chem. Int. Ed. 2003, 42, 3900. These oligomers showed mobilities up to  $0.43\text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ . However, OFETs based on most of these perfluoroaryl and perfluoroalkylaryl substituted materials were unstable in air or suffered from high threshold voltage. Fluorocarbonyl-functionalized oligomers were also described, which showed improved air stability, but lower electron mobilities with respect to fluorinated oligomers.

20 Oligomers and polymers containing a bithiophene-imide units as inner core have also been described.

25 For example, J. Am. Chem. Soc. 2008, 130, 9679-9694 describes N-alkyl-2,2'-bithiophene-3,3'-dicarboximide-based homopolymers and copolymers showing p-type or n-type semiconductor behavior depending on the polymeric structure. However, no air-stable devices could be achieved with such materials. In addition, the poor reactivity 30 of the starting dihalogenated bithiophene-imide compounds limits the accessibility of this class of materials.

J.Am.Chem.Soc. 1998, 120, 5355-5362, Tetrahedron Letters 44 (2003)1653-1565 disclose copolymers containing electron poor 3,4-imido-thienyl blocks alternated to electron rich amino substituted thienyl blocks. No investigation was performed regarding the electrical properties of such copolymers.

5 N-alkylated poly(dioxopirrolothiophene)s are described in Organic Letters 2004, 6, 19, 3381-3384. However, no proof of an efficient n-type behavior in OFET devices is reported.

Each of the afore mentioned class of materials has poor electrical performances.

WO2008/127029 relates to dioxopirrolo-heterocyclic compounds having the 10 pyrrole moiety fused to the 3,4 position of the thienyl ring and organic electronic devices using said dioxopirrolo-heterocyclic compounds.

Wei Hong et al, "Linear fused dithieno [2,3-b: 3'2'-d]thiophene diimides" Organic Letters, vol 13, no. 6, 18 March 2011, pages 1420-1413, discloses a class of linear fully fused dithieno thiophene diimides.

15 The documents: DE1954550; Ronova Iga A et al: "The effect of conformational rigidity on the initial decomposition temperature of some heterocyclic polyimides", High Performance Polymers, Institute of Physics Publishing, Bristol GB, vol. 14, No. 2, 1 January 2002, pages 195-208; and Gaina C. et al, "Polyimides containing 1,4-dithiine units and their corresponding thiophene 2,3,4,5 tetracarboxylimide units" High

20 Performance Polymers, Institute of physics publishing, Bristol GB, vol. 11, No. 2, 1 June 1999, pages 185-195, disclose polymeric diimide compounds in which the member connecting the polymer repeating units is the N-imidic substituent. The three last cited documents do not mention any semiconductor property of the compounds therein disclosed.

25 WO2006/094292 discloses thienopyridine compounds capable of modulating the stability and/or activity of hypoxia inducible factor, pharmaceutical compositions comprising said compounds and chemical intermediates useful for preparing said compounds. Among said chemical intermediates, specific compounds having a 4,6-dioxo-thieno[2,3-c]pyrrole nucleus are disclosed.

30 EP0467206 discloses specific compounds having a 4,6-dioxo-thieno[2,3-c]pyrrole nucleus and their use as herbicide.

However, WO2006/094292 and EP0467206 do not teach the semiconductor properties of said compounds.

Therefore, there is still the need of n-type organic semiconductor materials or 5 compounds that possess higher electron mobility properties.

In the present specification and in the claims, the term “n-type organic semiconductor” means a material that, inserted as active layer in a field effect device architecture with a source, a drain and gate control electrodes, shows an electron mobility higher than  $10^{-7} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ .

10 It is an object of the present invention to provide new organic materials suitable for use as semiconductor material, which is free from said disadvantages. Said object is achieved with a compound whose main features are disclosed in the first claim, a process for the preparation of said compound whose main features are disclosed in claim 10, a use of said compound whose main features are disclosed in claim 11 and an 15 electronic device whose main features are disclosed in claim 14. Other features of said compound are disclosed in claims 2 to 9.

Advantageously, the compounds according to the present invention may be useful as p-type, n-type or ambipolar organic semiconductor material.

Particularly, the compounds according to the present invention possess high 20 electron mobility properties, excellent stability under atmospheric conditions and are accessible through synthetically easy processes.

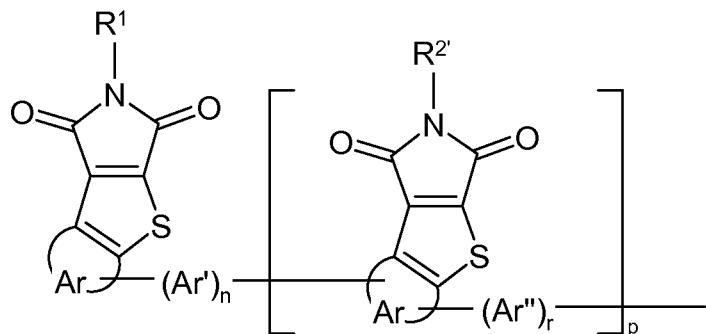
Further advantages and features of the compounds, materials and devices according to the present invention will become clear to those skilled in the art from the following detailed and non-limiting description of an aspect thereof with reference to 25 the attached drawings, wherein:

- figure 1 a) shows normalized absorption of a solution and film of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];
- figure 1 b) shows normalized emission of a solution and film of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];

- 5 -

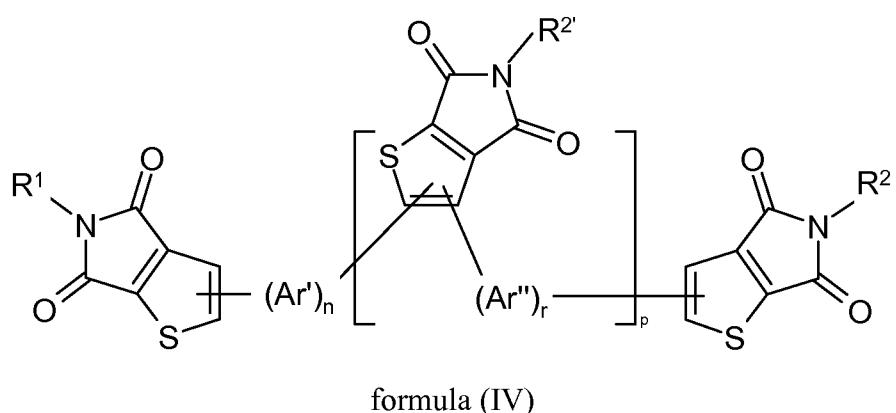
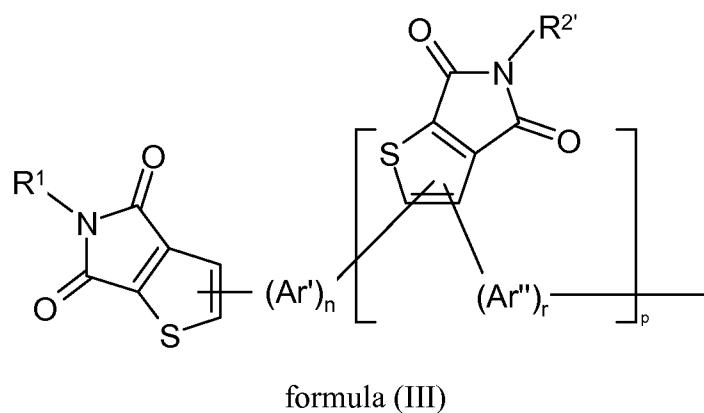
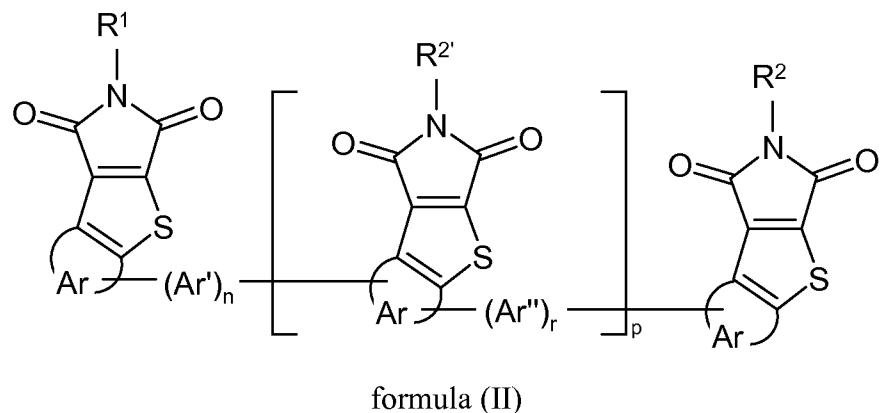
- figure 1 c) shows the CV curves for said compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];
- figure 2 is a DCS thermogram of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];
- figure 3 a), b), c), d), e) and f) show POM micrographs of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)] in different phases;
- fig. 4 a), b) and c) show single crystal structure and molecular packing of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];
- fig 5 a), b) and c) show AFM images of films of different thicknesses of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)];
- fig. 6 a), b) c) and d) show XRD patterns of a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)] in different forms; and
- fig. 7 a), b), c), d) and e) show graphs reporting the optoelectronic features of an OTFT comprising a compound according to the present invention [2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)] as semiconductor layer.

According to an aspect of the present invention, a compound of formula (I) or (II) or (III) or (IV) is provided:



formula (I)

- 6 -



wherein:

10 R<sup>1</sup>, R<sup>2</sup>, R<sup>2</sup>' independently of each other, are selected in the group consisting of hydrogen, C<sub>1</sub>-C<sub>40</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched heteroalkyl groups, C<sub>3</sub>-C<sub>40</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxamide groups,

C<sub>1</sub>-C<sub>40</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>40</sub> linear or branched nitrile groups;

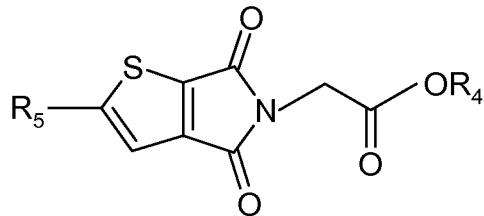
Ar is selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

5 Ar', Ar'', independently of each other, are moieties selected in the group consisting of a monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

n, r, independently of each other, are integers between 1 and 50; and

p is an integer between 0 and 5;

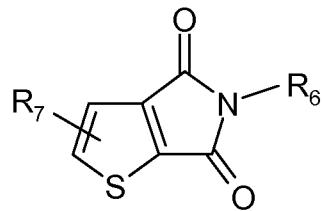
10 with the exception of compounds of formula A:



formula A

wherein R<sub>4</sub> is selected in the group consisting of C<sub>1</sub>-C<sub>4</sub> alkyls; and R<sub>5</sub> is selected in the group consisting of monocyclic aryl groups and substituted monocyclic aryl groups;

15 and with the exception of compounds of formula B:



formula B

wherein R<sub>6</sub> is selected in the group consisting of isopropyl, cyclopropyl and terbutyl groups and R<sub>7</sub> is selected in the group consisting of phenyl, 2-fluorophenyl, 3-fluorophenyl, 4-fluorophenyl, 2-chlorophenyl, 3-chlorophenyl, 4-chlorophenyl, 2-methylphenyl, 3-methylphenyl, 4-methylphenyl, 2-trifluoromethylphenyl, 3-trifluoromethylphenyl, 4-trifluoromethylphenyl, 2-methoxyphenyl, 3-methoxyphenyl, 4-methoxyphenyl, 2,4-dichlorphenyl, 2,4,6-

- 8 -

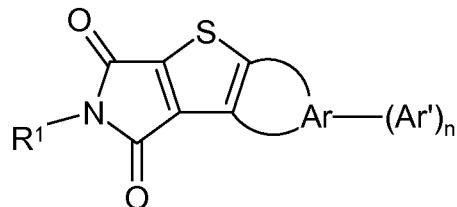
trimethylphenyl, 2-thienyl, 3-thienyl, 2-pyridyl, 3-pyridyl, 4-pyridyl.

The value of p is preferably 0, 1 or 2.

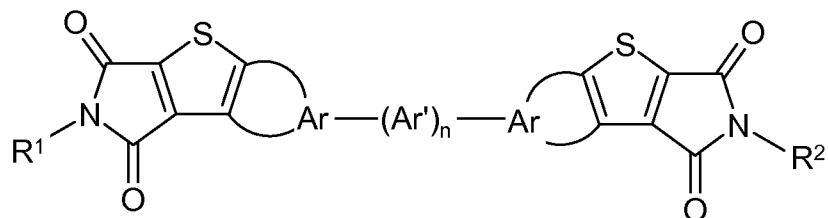
The values of n and r are preferably comprised between 2 and 50, more preferably between 2 and 30, even more preferably between 2 and 10 .

5 When p assumes the values of 0, then n is particularly preferably comprised between 2 and 50, more preferably between 2 and 30, even more preferably between 2 and 10 .

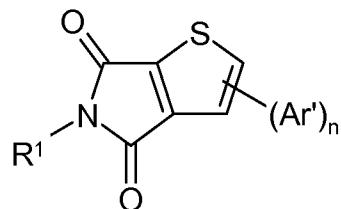
According to an aspect of the present invention, the compounds of following formulas (Ia), (IIa), (IIIa) and (IVa) are provided, which correspond to those of formulas 10 (I), (II), (III); (IV) wherein p is equal to 0:



formula (Ia)

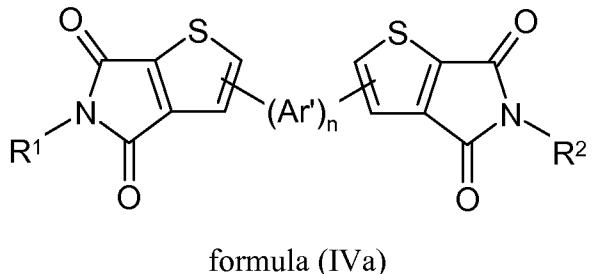


15 formula (IIa)



formula (IIIa)

- 9 -



wherein R<sup>1</sup>, R<sup>2</sup>, Ar, Ar' and n are as above defined.

5

In the present description and in the claims, the curved lines in formulas (I), (Ia), (II) and (IIa), connecting the Ar moiety to the imidothiophene unit, indicate that said Ar moiety forms a fused ring system with said imidothiophene unit.

In addition, as usual in chemical drawing practice, in the present description and 10 in the claims the bond line crossing the thiophene double bond in formulas (III), (IIIa), (IV) and (IVa) indicates that the (Ar')<sub>n</sub> moiety may be bound to any of the 2 or 3 position in the thiophene ring and is not fused thereto. Preferably, the (Ar')<sub>n</sub> moiety is bound to the 2 position of the thiophene ring.

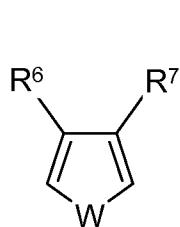
Further, as usual in chemical drawing practice, in the present description and in 15 the claims the bond line crossing the square parenthesis in formulas (I) and (III) is intended to indicate the position of binding of the various repeating units of the polymer. The repeating unit indicated within parenthesis is also one of the terminal units of the polymer.

In formulas (I), (Ia), (II) and (IIa), the (Ar')<sub>n</sub> moiety may be bound to any position 20 of the Ar moiety that is fused to the imidothiophene unit.

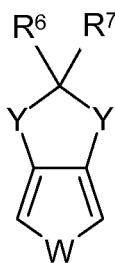
Preferably, Ar' is a thiophene unit or substituted thiophene unit.

For example, Ar' is a unit selected among the following (a), (b), (c):

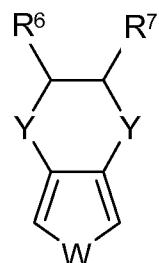
- 10 -



(a)



(b)



(c)

wherein W is selected in the group consisting of S, SO and SO<sub>2</sub>;

Y is selected in the group consisting of S, O, NR<sup>8</sup>; and

R<sup>6</sup>, R<sup>7</sup>, and R<sup>8</sup> independently of each other, are selected in the group consisting of

5 hydrogen, C<sub>1</sub>-C<sub>12</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched halogenoalkyl groups, C<sub>3</sub>-C<sub>12</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>12</sub> linear or branched

10 nitrile groups.

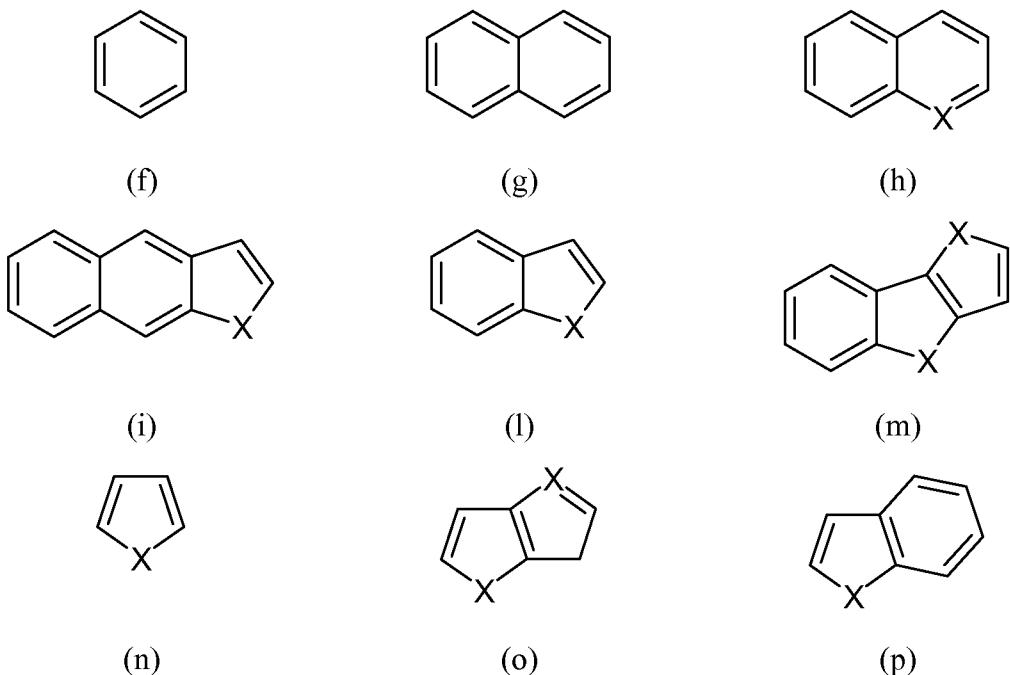
More preferably, the (Ar')<sub>n</sub> moiety is a linear chain of  $\alpha$ -linked thiophene units.

In formulas (I), (Ia), (II) and (IIa), the integer n is preferably comprised between 1 and 30, more preferably between 2 and 30, even more preferably between 2 and 10.

The compounds according to the invention wherein n is 2 are characterized by an 15 advantageously high solubility in a number of solvents, for example dichloromethane, dimethyl sulfoxide, tetrahydrofuran.

The Ar moiety fused to the imidothiophene unit of the compounds of formulas (I), (Ia), (II), and (IIa) according to the present invention may be advantageously formed of one, two or three aromatic rings.

20 Preferably, in formulas (I), (Ia), (II), and (IIa), Ar is selected in the group consisting of the following rings (f), (g), (h), (i), (l), (m), (n), (o), (p):



wherein X is selected in the group consisting of S, O, Si, Se, NR<sup>3</sup>,

$R^3$ , is selected in the group consisting of C<sub>1</sub>-C<sub>12</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched halogenoalkyl groups, C<sub>3</sub>-C<sub>12</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>12</sub> linear or branched nitrile groups.

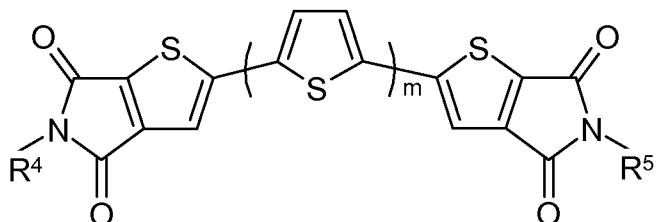
Preferably,  $R^1$ ,  $R^2$ , independently of each other, are selected in the group consisting of  $C_1$ - $C_{12}$  linear or branched alkyl groups,  $C_1$ - $C_{12}$  linear or branched heteroalkyl groups,  $C_3$ - $C_{12}$  linear or branched cycloalkyl groups,  $C_1$ - $C_{12}$  linear or branched hydroxyalkyl groups,  $C_1$ - $C_{12}$  linear or branched alkoxy groups,  $C_1$ - $C_{12}$  linear or branched alkylcarboxylic groups,  $C_1$ - $C_{12}$  linear or branched alkylcarboxamide groups,  $C_1$ - $C_{12}$  linear or branched alkylsulphonic groups, and  $C_1$ - $C_{12}$  linear or branched nitrile groups.

15 More preferably, R<sup>1</sup>, R<sup>2</sup>, independently of each other, are selected in the group consisting of C<sub>1</sub>-C<sub>12</sub> linear or branched saturated alkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched fluoroalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched heteroalkyl groups comprising a heteroatom selected among O, S, N.

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Preferably, in formulas (II), (IIa), (IV) and (IVa), R<sub>1</sub> is the same as R<sub>2</sub>.

According to a preferred aspect of the invention, a linear  $\alpha$ -linked oligothiophene di-imide compound of formula (V) is provided:



5

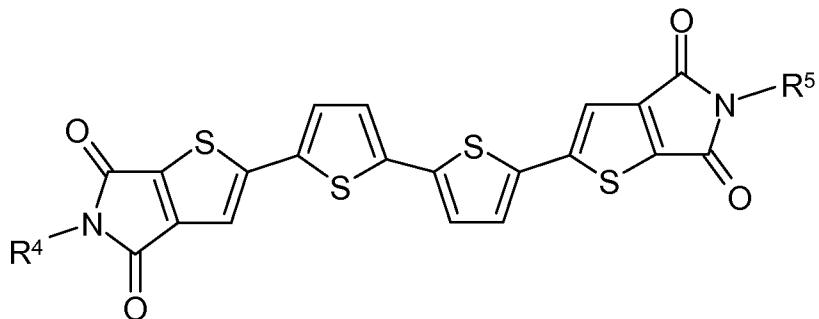
formula (V)

wherein R<sup>4</sup>, R<sup>5</sup> are selected in the group consisting of C<sub>1</sub>-C<sub>8</sub> linear or branched saturated alkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched fluoroalkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched heteroalkyl groups comprising a heteroatom selected among O, S, N; and

10 m is an integer between 1 and 50.

More preferably, in compound of formula (V), m is comprised between 1 and 30, more preferably between 2 and 30, even more preferably, m is comprised between 2 and 10.

15 According to a more preferred aspect of the invention, a compound is provided having formula (VI):



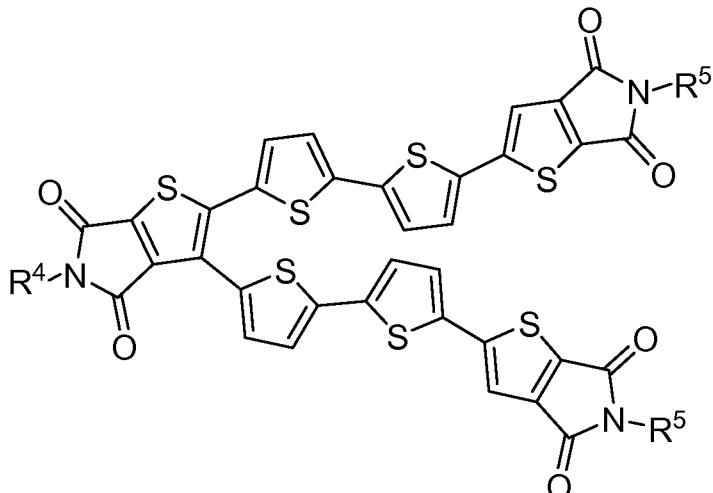
formula (VI)

20

wherein R<sup>4</sup>, R<sup>5</sup> are as above defined with reference to formula (V).

According to another preferred aspect of the invention, a compound is provided

having formula (VII):



formula (VII)

5

wherein  $R^4$ ,  $R^5$  are as above defined with reference to formula (V).

As it may well be understood, the compound of formula (VII) derives from general formula (IV) wherein  $p$  is equal to 1;  $n$  and  $r$  are equal to 2;  $Ar'$  and  $Ar''$  are thiophene,  $R^1$  and  $R^2$  are  $R^5$ ; and  $R^{2'}$  is  $R^4$ .

10 Without wishing to limit the present invention to any theory, it is believed that the imido-thiophene moiety allows for the combination of the strong electron-withdrawing effect of the carboxylic groups, which contributes in lowering the LUMO energy level of the final oligomer, to the chemical versatility, robustness and plasticity of the thiophene ring. This allows the realization of novel  $\alpha$ -conjugated materials with high electron 15 affinities comparable to the currently more performing n-type semiconducting organic materials.

Among the main advantages of such compounds with respect to other classes of n-type materials are to be mentioned the easy accessibility and structural versatility.

As a matter of fact, the imide moieties can be easily fused to the thiophene ring, as 20 described below. The imido-thiophene moiety can easily be mono- or dihalogenated to realize linear oligomers.

Finally N-substitution, particularly with linear, branched alkyl, heteroalkyl and

perfluoroalkyl chains can be easily achieved by standard chemistry and exploited to tune solubility, self-organization and optoelectronic properties.

The advantage of the compounds of formulas (I) and (II), wherein the imido-thiophene block is inserted into fused heterocycles with high degree of  $\alpha$ -conjugation and planar structure, is that further tuning of the electronic levels as well as the morphology and optoelectronic properties of the final oligomers are possible.

The thiophene-imide moiety can be coupled to selected  $\pi$ -conjugated cores by cross-couplings under conventional or microwave-assisted methods as described below.

The easy accessibility of the compounds according to the invention also allows an easy modification of the oligomer size, and degree and type of molecular functionalization, which in turn permits to tailor the compounds properties as a function of the particular requirements of the desired application.

The compounds according to the present invention can be obtained with electronic level of purity by chromatography, crystallization and sublimation, with unambiguous molecular structure determination through classic analytical methods.

Contrarily to the thiophene-3,4-imide polymers, bithiophene-imide polymers and perylene tetracarboxylic diimide systems according to the prior art, this class of materials can be prepared with high reproducibility from batch to batch, which is crucial to achieve devices with reproducible responses. In addition, they can be adapted to solution processing by inserting tailored alkyl or alkoxy-chains as N-substituents.

Another advantage of the compounds according to the present invention consists in its high self-organization capability and order in thin films, due to their chemical structure comprising an imide moiety as alpha-end-substituent rather than beta inner substituent.

According to still another aspect of the invention, it is provided a process for the production of a compound according to the invention, wherein the process comprises: subjecting a reaction mixture comprising a reaction medium and an halogenated aromatic halide to: a Stille coupling reaction with an organotin compound; or to a Suzuki coupling reaction with an organoboron compound.

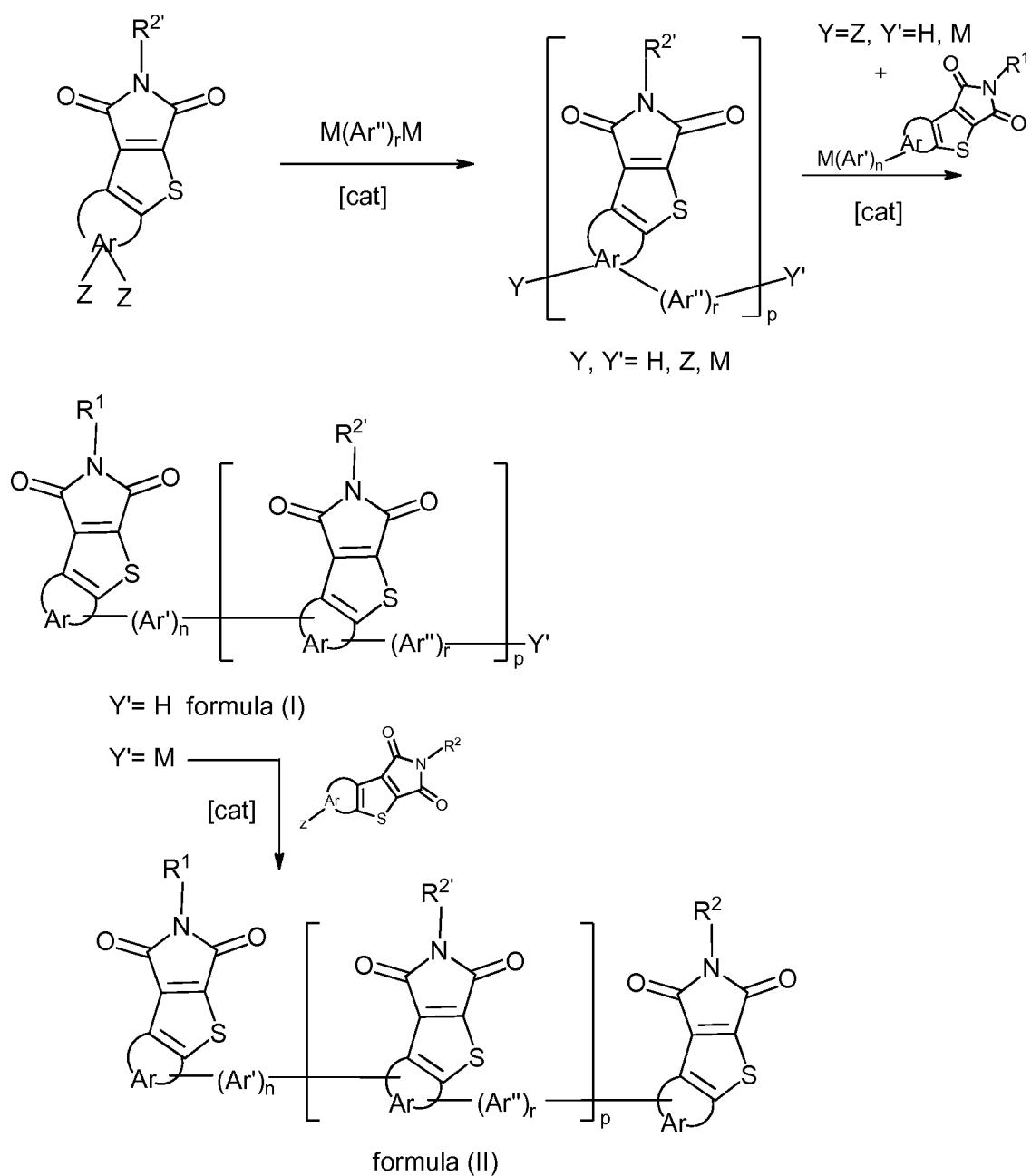
The processes according to the present invention are preferably catalyzed by palladium.

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The compounds according to the invention of formulas (I), (II), (III), and (IV) may be obtained starting from a dihalogenated aromatic halide, such as in the following Schemes 1 and 2:

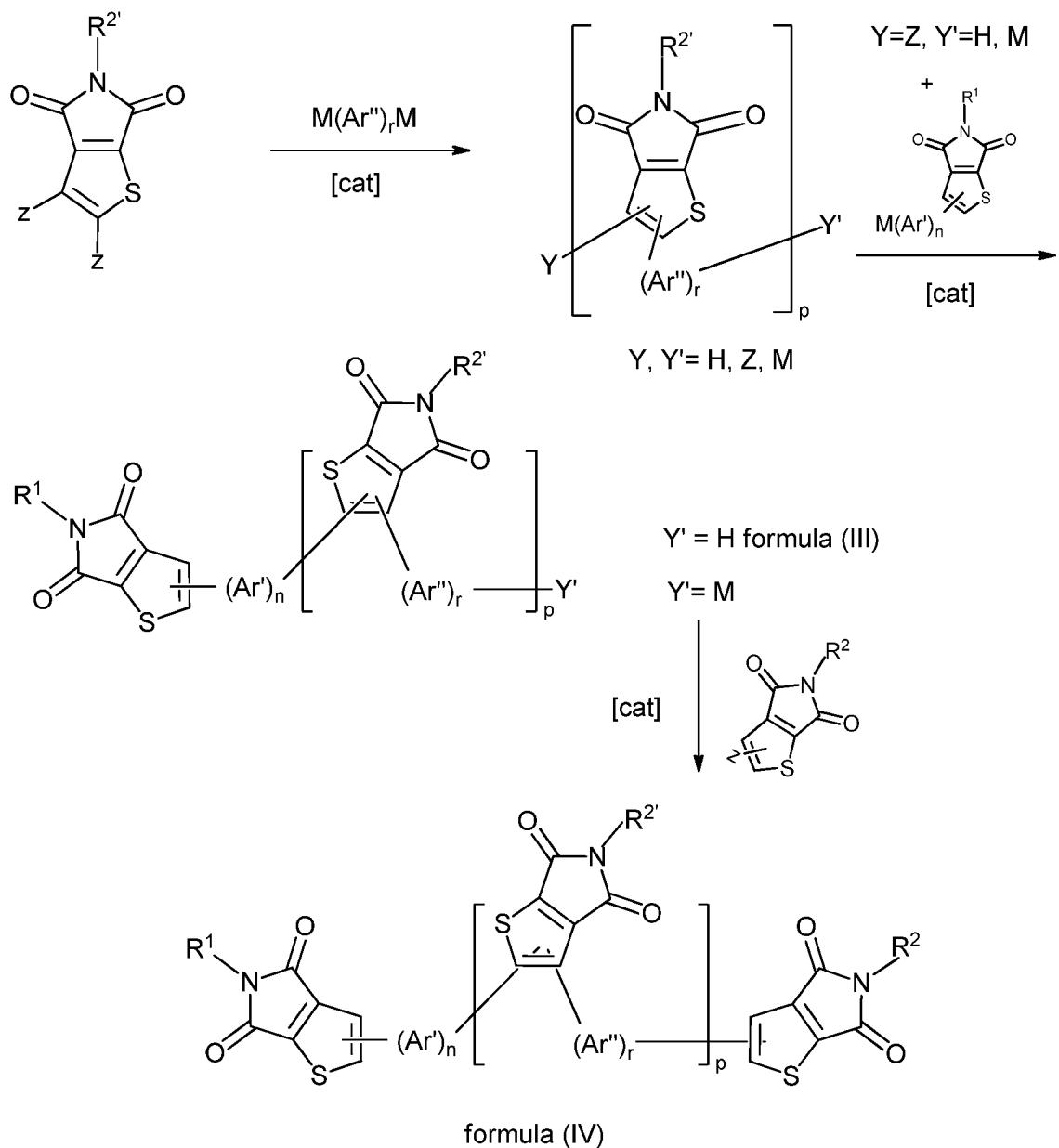
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Scheme 1



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Scheme 2

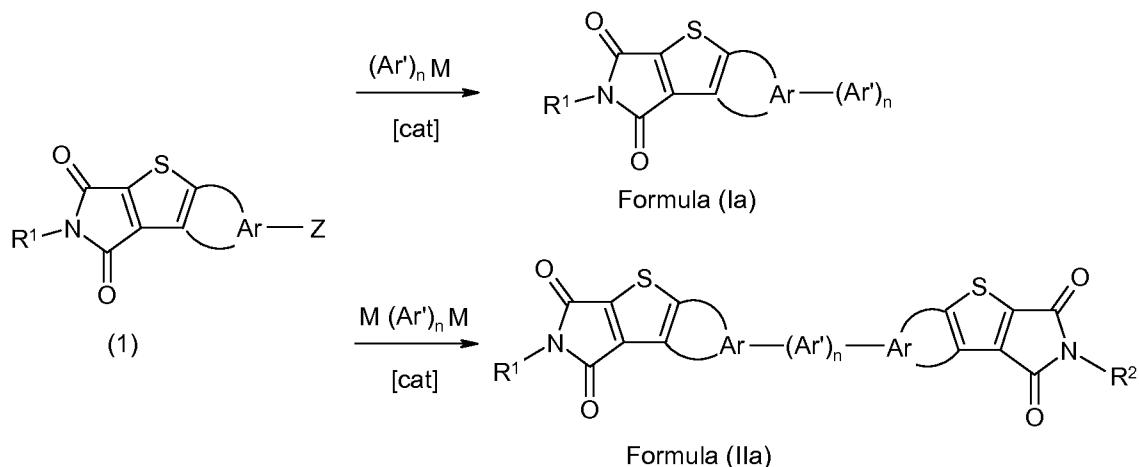


5 wherein Z is selected among halogen atoms, such as Br, I; M is an organometal compound such as  $B(OR')_2$  and  $SnR''_3$ ; and [cat] is a palladium based catalyst.

The compounds of formulas (Ia), (IIa), (IIIa) and (IVa) may be obtained according to the present invention by means of processes as outlined in the following Schemes 3 and 4:

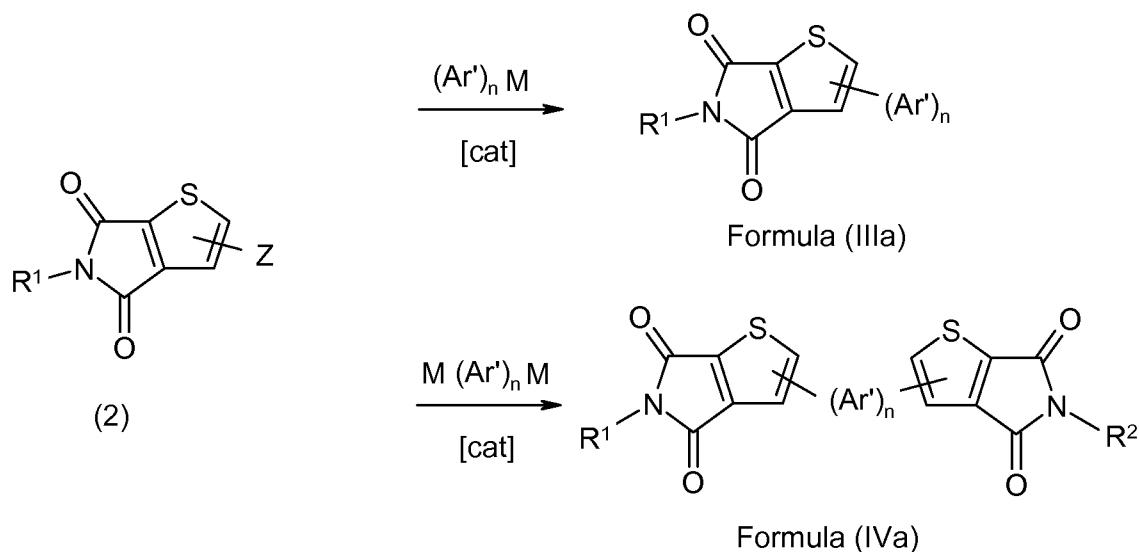
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Scheme 3



5

Scheme 4



10 wherein  $\text{Z}$  is selected among halogen atoms, such as  $\text{Br}$ ,  $\text{I}$ ;  $\text{M}$  is an organometal compound such as  $\text{B}(\text{OR}')_2$  and  $\text{SnR}''_3$ ; and [cat] is a palladium based catalyst. For example, tetrakis triphenylphosphine palladium (0) can be used as catalyst.

The molecular symmetry of the compounds affects the self-organization motifs and morphology of the molecules in the solid state, thus the final functional properties.

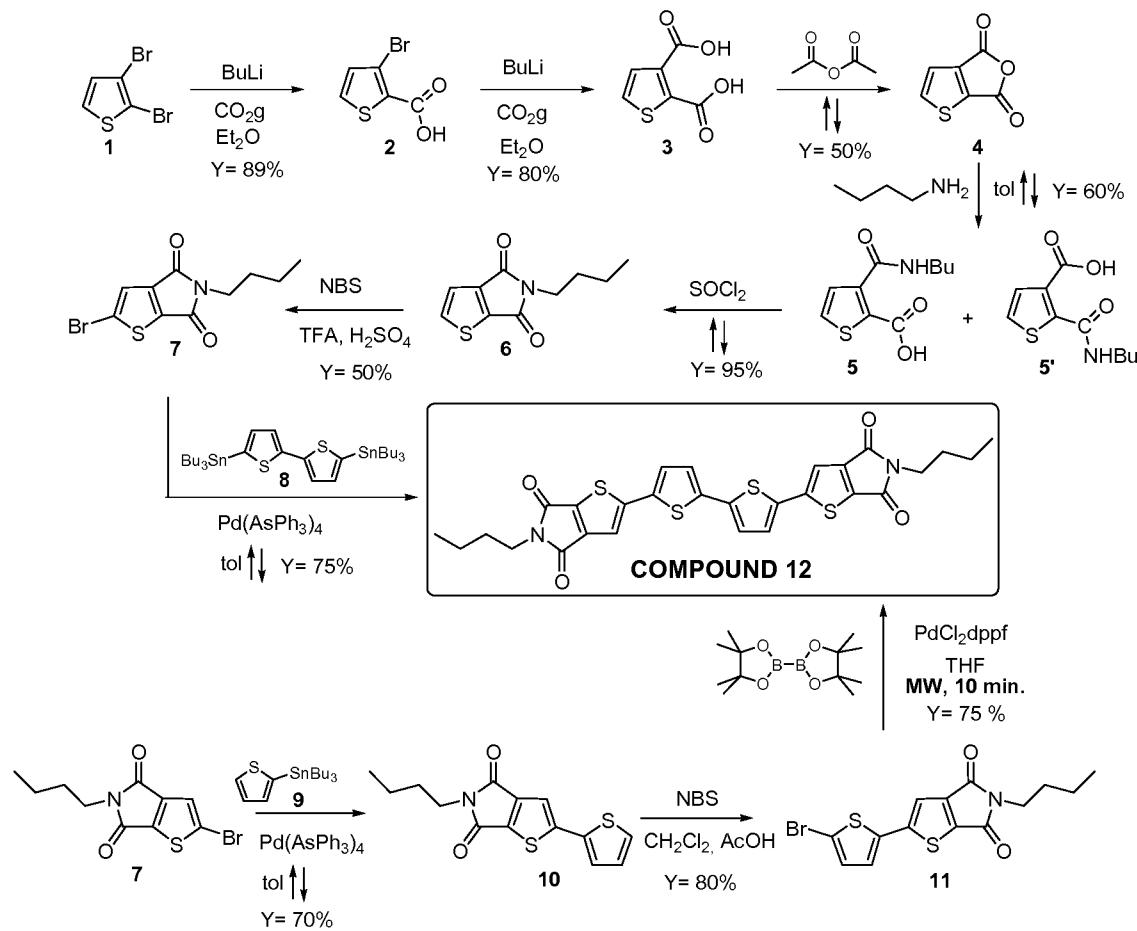
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In the above schemes, the symmetry of the final compounds can be controlled by changing the synthetic approach. Cross-coupling reaction between mono-halogenated thiophene-imide unit and monometallic species lead to asymmetric systems (Ia) and (IIIa). On the other hand, by using bimetallic species a symmetric system can be obtained, provided that the N-substituting radical R<sup>1</sup> and R<sup>2</sup> are the same.

5 In detail, the synthesis of a preferred compound 12, of formula (VI) according to the present invention, is outlined in the following Scheme 5.

Scheme 5

10



This scheme outlines the preparation of compound 12 according to the present invention, a thiophene based oligomer in which the aromatic core Ar' consists of a 2,2'-bithiophene, the N-substituent is a n-butyl group and the terminals are symmetric imide moieties. Two synthetic routes to the target oligomer have been developed and

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- 19 -

are depicted the above Scheme 6. The first method is based on the Stille cross coupling reaction between a bistannyl-bithiophene **8** and the brominated thiophene-imide block **7** under conventional heating. The second route consists of microwave assisted one-pot borylation-Suzuki coupling starting from the brominated thiophene-imide-thiophene 5 dimer. The latter method affords higher yields in only 10 minutes of microwave irradiation (P= 300 W, T= 80°C) and appears more convenient also in terms of product purity since no- Sn side-products, requiring tedious purification steps, are formed.

In detail, the thiophene-imide starting unit **6** can be prepared by the corresponding anhydride **4**, following prior art processes. Bromination of **6** can be achieved under 10 harsh conditions by using a mixture of trifluoroacetic and sulphuric acids. Following Stille cross-coupling of compound **7** with tributylstannilthiophene **9**, leads to the dimer **10** in satisfying yield, which can be then brominated under conventional halogenations reaction conditions to give **11** in satisfying yield. By the first outlined method, the target 15 oligomer compound **12** can be then prepared by one-pot microwave assisted borylation/Suzuki coupling reactions by using bispinacol borate as borylating agent and PdCl<sub>2</sub>dppf as Pd [0] source.

Compound **12** shows good solubility in common organic solvents (i.e. dichloromethane, toluene, tetrahydrofuran) allowing for solution processing. The purification to electronic grade material can be achieved by repeated vacuum 20 sublimation.

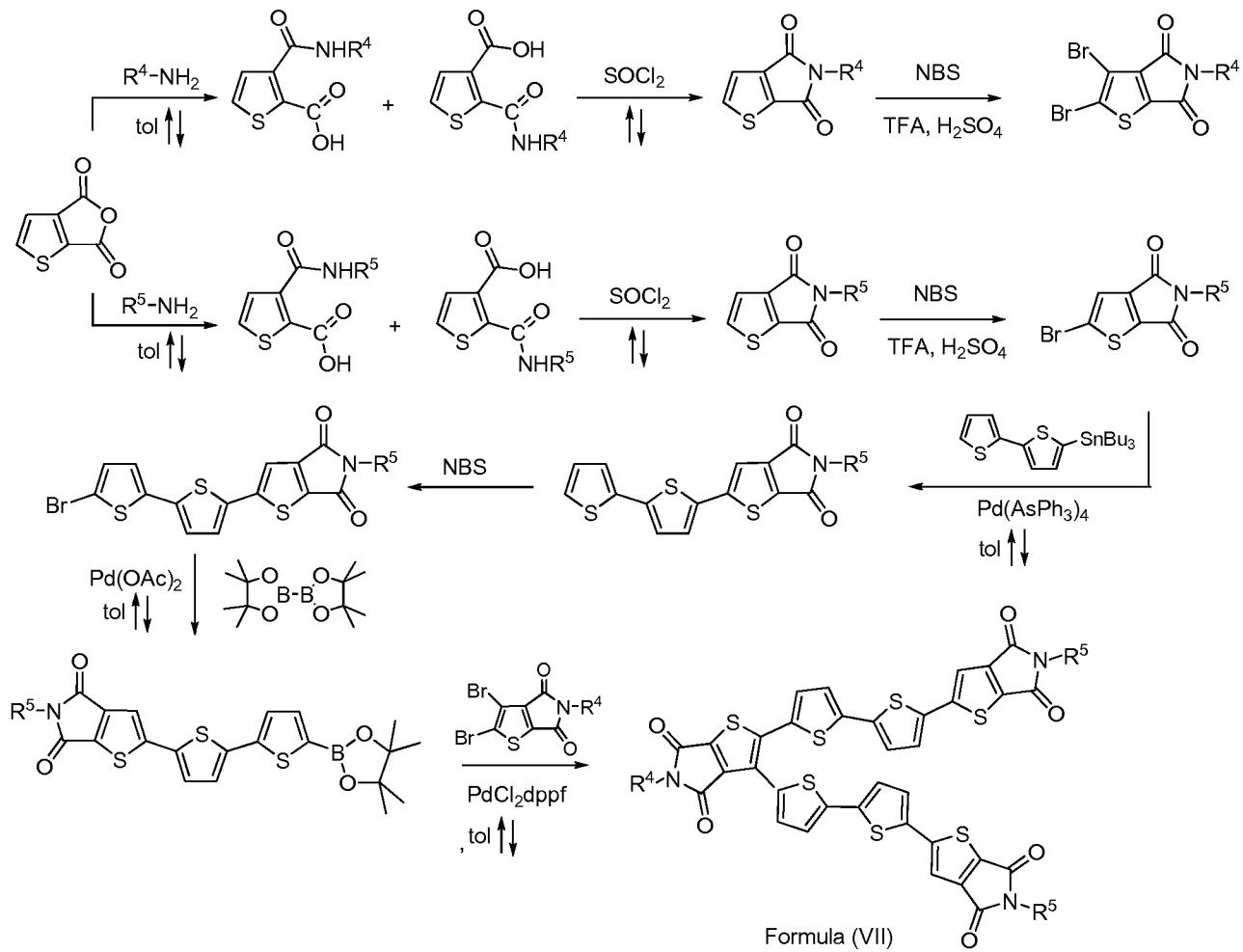
The compounds of formula (VII) may be obtained according to the following Scheme 6:

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- 20 -

Scheme 6



5 In another aspect thereof, the present invention relates to a semiconductor material, comprising at least one compound according to formulas (I); (II); (III); or (IV). Preferably, said semiconductor material comprises at least one compound according to formulas (Ia); (IIa); (IIIa); or (IVa). More preferably, said semiconductor material, comprises at least one compound according to formulas (V), (VI) or (VII).

10 In an embodiment thereof, said semiconductor material comprises compound 12.

According to another aspect, the invention relates to an electronic device comprising a semiconductor layer in contact with a number of electrodes, wherein the semiconductor layer includes at least one compound according to formulas (I); (II); (III); or (IV). Preferably, said semiconductor layer comprises at least one compound

according to formulas (Ia); (IIa); (IIIa); or (IVa). More preferably, said semiconductor layer, comprises at least one compound according to formulas (V), (VI) or (VII).

In an embodiment thereof, said semiconductor layer comprises compound 12.

Preferably, said electronic device comprising a semiconductor layer including the 5 compounds according to the present invention is selected among optical devices, electrooptical devices, field effect transistors, integrated circuit, thin film transistors, organic light-emitting devices, and organic solar cells.

Particularly, thin films of the thiophene-imide based materials according to the invention can be used as active layers in OFETs and OLET devices as demonstrated in 10 the following examples. They can be used as electron- or hole- transporting layer or ambipolar transporters in single layer OFET, as multifunctional electron- and hole-transporting and light emitting layer in single layer OLET, and as hole or electron transporting layer in multi-layer OLET.

Finally, applications of compounds and materials according to the present 15 invention in organic photovoltaics can be envisaged.

In the following examples, microwave experiments were carried out in a Milestone Microsynth Labstation operating at 2450 MHz monitored by a proprietary control unit. The oven was equipped with magnetic stirring, pressure and temperature sensors. Reactions were performed in a glass vessel (capacity 10 mL) sealed with a 20 septum. The microwave method was power controlled and the samples were irradiated with the required power output (setting at the maximum power) to achieve the desired temperature. All <sup>1</sup>H NMR, <sup>13</sup>C NMR spectra were recorded at room temperature on a Varian Mercury-400 spectrometer equipped with a 5-mm probe. Flash chromatography was carried out using silica gel (200-300 mesh ASTM). Analytical thin layer 25 chromatography (TLC) was carried out using 0.2 mm sheets of silica gel 60 F254 and the visualization accomplished by UV light (356 nm and 254 nm). Melting points were determined on a Kofler bank apparatus and are uncorrected.

Example 1: Preparation of 3-bromothiophene- 2-carboxylic acid

To a solution of nBuLi (2.5 M, 0.055 mol, 22 ml) in dry Et<sub>2</sub>O (15 ml) at -78°C in 30 N<sub>2</sub> atmosphere, 2,3-dibromothiophene (12.1 g, 0.025 mol) was added drop wise. After ten minutes from the addition of the last portion, gaseous CO<sub>2</sub> was fluxed into the

solution and the formation of a white precipitate was immediately observed. The suspension was stirred for additional 30 minutes at -78°C, then was allowed to reach room temperature. The reaction was quenched by adding milliQ H<sub>2</sub>O, then the aqueous phase was extracted by NaOH 10% (3x 50 ml). Subsequently, HCl 6 N was added and 5 the precipitate formed was collected by filtration. Re-crystallization from EtOH (50 ml) and H<sub>2</sub>O (200 ml) and finally, drying under vacuum furnished 9.23 g of a white powder.

M.p. 191°C, MS (70 eV, EI): m/z 208 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>): δ ppm = 7.81 (d, 1 H, J = 5.2 Hz), 7.19 (d, 1 H, J = 5.2 Hz) <sup>13</sup>C NMR (CDCl<sub>3</sub>): δ ppm = 117.6, 133.8, 134.6, 162.6, 207.6.

10 Example 2: Preparation of thiophene-2,3-dicarboxylic acid

This compound was prepared according to the procedure used for the synthesis of 3-bromothiophene-2-carboxylic acid, starting from 5.18 g (0.025 mol) of 3-bromothiophene- 2-carboxylic acid and 30 ml (0.075 mol) of nBuLi. Recrystallization from EtOH/H<sub>2</sub>O afforded thiophene-2,3-dicarboxylic acid as white powder (Y=80%)

15 M.p. 268°C, MS (70 eV, EI): m/z 278 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub> + CS<sub>2</sub>, TMS): δ ppm = 7.89 (d, 1 H, J = 5.2 Hz), 7.71 (d, 1 H, J = 5.2 Hz) .

Example 3: Preparation of thiophene-2,3-dicarboxylic anhydride

Thiophene-2,3-dicarboxylic acid (760 mg, 5 mmol) was dissolved in 20 ml of acetic anhydride and the solution was stirred overnight at 140°C. The reaction mixture 20 was subsequently concentrated to a pale brown solid which was recrystallized from toluene to afford thiophene-2,3-dicarboxylic anhydride (Y= 50 %) as pale yellow crystals.

25 M.p. 147.5°C, MS (70 eV, EI): m/z 155 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>): δ ppm = 8.43 (d, 1 H, J = 4.8 Hz), 7.58 (d, 1 H, J = 4.8 Hz). <sup>13</sup>C NMR (CDCl<sub>3</sub>): δ ppm = 123.3, 143.3, 145.4, 147.4, 158.7, 159.5, 206.9.

Example 4: Preparation of 2-butylcarbamoylthiophene-3-carboxylic acid, and 3-butylcarbamoylthiophene-2-carboxylic acid

A solution of thiophene-2,3-dicarboxylic anhydride (171 mg, 1 mmol) and n-butylamine (77 mg, 1.05 mmol) in 15 ml of toluene was refluxed for 24 h. The crude 30 products were collected by filtration of the cold reaction mixture. Another portion was achieved by washing the filtrate with 5 % hydrochloric acid and then evaporating the

solvent. Recrystallization from toluene afforded a mixture of 2-butylcarbamoylthiophene-3-carboxylic acid and 3-butylcarbamoylthiophene-2-carboxylic acid in 60 % yield as white solid which was used for cyclization without further purification.

5 MS (70 eV, EI): m/z 227 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>): δ ppm = 7.76 (d, 1 H, J = 5.2 Hz), 7.56 (d, 1 H, J = 5.2 Hz), 7.5 (1H, broad), 7.0 (1H, broad, -OH), 7.39 (m, 2H, -OH), 3.49 (m, 2H), 3.0 (1H, broad -NH), 1.8 (broad, 1H, -NH), 1.64 (m, 2H), 1.4 (m, 2H), 0.96 (m, 3H). <sup>13</sup>C NMR (CDCl<sub>3</sub>, TMS): δ ppm = 131.5, 126.5, 40.5, 31.1, 20.1, 13.7.

10 Example 5: Preparation of 5-butylthieno[2,3-c]pyrrole-4,6-dione

A solution of 2-butylcarbamoylthiophene-3-carboxylic acid, and 3-butylcarbamoylthiophene-2-carboxylic acid (136 mg, 0.6 mmol) in 12 ml of thionyl chloride was refluxed for 3 h. The reaction mixture was concentrated to a yellow oil. Flash chromatography on silica gel, by using petroleum ether: CH<sub>2</sub>Cl<sub>2</sub>:AcOEt = 6:2:2, afforded 5-Butylthieno[2,3-c]pyrrole-4,6-dione as dark yellow oil (124 mg, Y< 99%).

15 MS (70 eV, EI): m/z 209 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>, TMS): δ ppm = 7.74 (d, 1 H, J = 4.8 Hz), 7.27 (d, 1 H, J = 5.2 Hz), 3.57 (t, 2H), 1.59 (m, 2H), 1.33 (m, 2H), 0.91 (t, 3H). <sup>13</sup>C NMR (CDCl<sub>3</sub>, TMS): δ ppm = 163.8, 162.7, 144.6, 140.7, 137.2, 120.9, 38.1, 30.7, 19.9, 13.5.

20 Example 6: Preparation of 2-bromo-5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione

5-Butylthieno[2,3-c]pyrrole-4,6-dione (123 mg, 0.59 mmol) was dissolved in 4 ml of a 1:3 mixture of concentrated sulfuric acid and trifluoroacetic acid. NBS (116 mg, 0.65 mmol) was added in 3 portions over 3 hs and the reaction mixture was stirred at room temperature over night. The brown solution was then diluted with 40 ml of water and extracted with dichloromethane. The organic phase was dried over anhydrous magnesium sulfate and evaporated to afford the crude product as a brown oil. Purification by column chromatography using silica gel and petroleum ether: AcOEt (95:5) as eluent followed by recrystallization from aqueous ethanol gave the desired 2-bromo-5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione in 50% yield.

25 <sup>1</sup>H NMR (CDCl<sub>3</sub>): δ ppm = 7.29 (s, 1 H), 3.57 (t, 4 H), 1.6 (m, 24H), 1.33 (m, 4H), 0.92 (t, 3H).

Example 7: Preparation of 5-butyl-2-(thiophene-2-yl)-5H-thieno[3,2-c]pyrrole-4,6-dione

To a refluxing toluene solution (6 ml) of 2-bromo-5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione (101 mg, 0.35 mmol), in situ-prepared Pd(AsPh<sub>3</sub>)<sub>4</sub> (5 mol%, i.e. 9.0 mg of Pd<sub>2</sub>dba<sub>3</sub> and 21.4 mg of AsPh<sub>3</sub>] at 80°C under N<sub>2</sub> atmosphere, 2-(tributylstanny)thiophene (144 mg, 0.38 mmol) in toluene (2 ml), was added dropwise. The solution was refluxed for 2 h then the solvent was removed under vacuum and the crude product purified by flash chromatography on silica gel by using increasing amounts of EtOAc in petroleum ether as eluent. 5-Butyl-2-(thiophene-2-yl)-5H-thieno[3,2-c]pyrrole-4,6-dione was obtained as bright yellow microcrystals (76 mg, 75 %).

M.p. 143°C, MS (70 eV, EI): m/z 291 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>, TMS/ppm): 7.38 (dd, 3J=5.2 Hz, 4J=1.2 Hz, 1H), 7.32 (dd, 3J=3.6 Hz, 4J=1.2 Hz, 1H), 7.31 (s, 1H), 7.08 (dd, 3J=5.2 Hz, 3J=3.6 Hz, 1H), 3.60 (t, 2H), 1.63 (m, 2H), 1.36 (m, 2H), 0.94 (t, 3H). <sup>13</sup>C NMR (CDCl<sub>3</sub>, TMS/ppm): 164.0, 162.9, 145.1, 143.3, 137.4, 135.2, 128.3, 127.2, 126.1, 116.6, 38.3, 30.8, 20.0, 13.6.

Example 8: Preparation of 2-(5-bromothiophen-2-yl)-5-butyl-5H-thieno[3,2-c]pyrrole-4,6-dione

5-Butyl-2-(thiophene-2-yl)-5H-thieno[3,2-c]pyrrole-4,6-dione (70 mg, 0.24 mmol) was dissolved in 4 ml of a 1:1 mixture of dichloromethane and acetic acid solution. NBS (43 mg, 0.24 mmol) was then added in darkness, and the reaction mixture was stirred at room temperature over night. The yellow solution was then diluted with 10 ml of water, extracted with dichloromethane, washed with 10% NaHCO<sub>3</sub>, and water. The organic phase was dried over anhydrous sodium sulfate and evaporated to afford compound 10 as a bright yellow solid (88 mg, 99%) which was used without further purification.

M.p. 170°C, MS (70 eV, EI): m/z 370 (M. -1), <sup>1</sup>H NMR (CDCl<sub>3</sub>, TMS/ppm): 7.24 (s, 1H), 7.07 (d, 3J=3.6 Hz, 1H), 7.04 (d, 3J=3.6 Hz, 1H), 3.60 (t, 2H), 1.62 (m, 2H), 1.35 (m, 2H), 0.94 (t, 3H). <sup>13</sup>C NMR (CDCl<sub>3</sub>, TMS/ppm) 163.8, 162.7, 148.8, 145.1, 137.8, 136.5, 131.1, 126.2, 116.8, 114.4, 38.3, 30.8, 20.0, 13.6.

Example 9: Preparation of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione):

Route 1: To a refluxing toluene solution (8 ml) of 2-bromo-5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione (101 mg, 0.35 mmol), in situ-prepared  $\text{Pd}(\text{AsPh}_3)_4$  (6 mol%, i.e. 11.3 mg of  $\text{Pd}_2\text{dba}_3$  and 26.7 mg of  $\text{AsPh}_3$ ) at  $80^\circ\text{C}$  under  $\text{N}_2$  atmosphere, 5,5'-bis(tributylstanny)-2,2'-bithiophene, 8 (155 mg, 0.26 mmol) in toluene (2 ml), was added drop wise. The solution was refluxed for 24 h then the solvent was removed under vacuum and the crude product purified by flash chromatography on silica gel by using a solution of pet. eth. :  $\text{CH}_2\text{Cl}_2$  = 50: 50  $\rightarrow$  pet. eth. :  $\text{CH}_2\text{Cl}_2$ :  $\text{AcOEt}$  = 45:45:10 as the eluent. The target compound was obtained as a strong red powder (76 mg, 75 %) M.p.  $294^\circ\text{C}$ , MS (70 eV, EI): m/z 580 (M. -1), absorption maximum, 449 nm, emission maximum, 570 nm in DCM;  $^1\text{H}$  NMR ( $\text{CD}_2\text{Cl}_2$ , TMS/ppm): 7.36 (s, 2 H), 7.32 (d, 3J=4.0 Hz, 2H), 7.04 (d, 3J=4.0 Hz, 2H), 3.60 (t, 4H), 1.63 (m, 4H), 1.36 (m, 4H), 0.96 (t, 6H). Anal. Calcd for  $\text{C}_{28}\text{H}_{24}\text{N}_2\text{O}_4\text{S}_4$  (580.76): C, 57.91; H, 4.17. Found: C, 57.99; H, 4.27.

Route 2: A mixture of 5-butyl-2-(thiophene-2-yl)-5H-thieno[3,2-c]pyrrole-4,6-dione (37.0 mg, 0.1 mmol), bis(pinacolato)diboron (15.2 mg, 0.06 mmol), (dppf) $\text{PdCl}_2$  (4.1 mg, 0.005 mmol),  $\text{NaHCO}_3$  (21.0 mg, 0.25 mmol) in THF/water 5:1 (3.6 mL) was irradiated with microwaves at  $80^\circ\text{C}$  for 20 min. After cooling to room temperature, a TLC monitoring showed the absence of starting material 10. After evaporation of the solvent in vacuo, the crude mixture was washed in pentane to remove the excess of boron, then dissolved in toluene and filtered over silica gel to remove the catalyst. Recrystallization from hot toluene gave compound 11 in 75 % yield. M.p.  $296^\circ\text{C}$ , Anal. Calcd for  $\text{C}_{28}\text{H}_{24}\text{N}_2\text{O}_4\text{S}_4$  (580.76): C, 57.91; H, 4.17. Found: C, 57.95; H, 4.20.

Example 10: Registration of absorption, emission and electrochemical properties of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione).

UV-vis and fluorescence (PL) spectra of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) (compound 12) were recorded with a JASCO V-550 spectrophotometer. Photoluminescence was excited using a CW He-Cd laser at 440 nm with 20 mW power. PL excitation was truncated with a GG450 cut-off filter without modulating the PL spectra. PL emission was collected with a calibrated optical

multichannel analyzer (PMA-11, Hamamatsu).

Redox potentials of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione), 12 have been measured at room temperature on 1.5 mmol·l<sup>-1</sup> solution in CH<sub>2</sub>Cl<sub>2</sub> (Carlo Erba RPE, distilled over P<sub>2</sub>O<sub>5</sub> and stored under Ar pressure) with 0.1 mmol·l<sup>-1</sup> (C<sub>4</sub>H<sub>9</sub>)<sub>4</sub>NClO<sub>4</sub> (Fluka, puriss. crystallized from CH<sub>3</sub>OH and vacuum dried). After Ar bubbling, CVs were performed at scan rates within 0.01 and 0.2 V·s<sup>-1</sup>, in a home-made three compartment glass cell under Ar pressure, by using an AMEL electrochemical system model 5000. Working electrode was semi-spherical Pt, auxiliary electrode was a Pt wire, and reference electrode was aqueous KCl Saturated Calomel Electrode (SCE). The standard potentials have been evaluated as the average of the potentials of the maxima of the forward and backward waves.

The normalized absorption and emission spectra of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) (compound 12) in 4x10<sup>-5</sup> CH<sub>2</sub>Cl<sub>2</sub> solution and 100 nm thick film are shown in FIG 1a,b respectively. The solution and film spectra were similar, suggesting high molecular planarity and rigidity. The absorption maximum is located at about  $\lambda_{\text{max}} = 440$  nm in solution and  $\lambda_{\text{max}} = 470$  nm in film, strongly red shifted with respect to dihexyl substituted quaterthiophene ( $\lambda_{\text{max}} = 401$  nm) and diperfluorohexyl quaterthiophene ( $\lambda_{\text{max}} = 398$  nm) highlighting the strong electron-withdrawing feature of the di-imide moieties. Similarly, the emission maximum  $\lambda_{\text{em}}$  is located at 579 nm ( $\lambda_{\text{exc}} = 449$  nm) in solution and  $\lambda_{\text{em}} = 603$  nm in film, strongly red-shifted with respect to the alkyl substituted analogue.

The cyclic voltammetry (CV) in CH<sub>2</sub>Cl<sub>2</sub> 0.1 mol l<sup>-1</sup> (C<sub>4</sub>H<sub>9</sub>)<sub>4</sub>NClO<sub>4</sub>, of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) (compound 12) and peak currents as a function of the square root of the scan rate is shown in FIG. 1c. At scan rate  $v = 0.2$  Vs<sup>-1</sup>, the potentials of the reduction and oxidation wave maxima resulted -1.33 and 1.42 V vs. SCE, respectively. The standard potentials resulted  $E^{\circ}_{\text{red}} = -1.21$  V and  $E^{\circ}_{\text{ox}} = 1.32$  V vs. SCE that gives an electrochemical energy gap  $E_{\text{elec}} = 2.53$  eV (close to the  $E_{\text{gopt}} = 2.4$  eV) and a HOMO energy value of -6 eV and a LUMO one of -3.4 eV. Correlation coefficient of peak currents vs.  $v^{-1/2}$  linear fits are >0.997 and the differences of the slopes for the oxidation and reduction peaks are

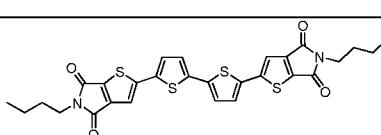
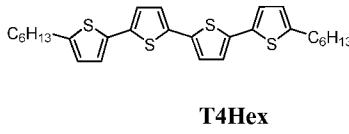
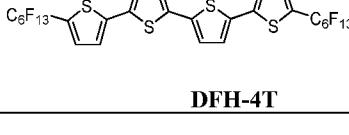
<15%, the resulting diffusion coefficient is  $2.9 \times 10^{-3} \text{ cm}^2 \text{ s}^{-1}$ .

Spectroscopic and cyclovoltammetry data are summarized in Table 1 and are compared to those of hexyl substituted quaterthiophene (T4Hex) and to those of the known thiophene-based n-type organic semiconductor  $\alpha,\omega$ -diperfluorohexyltetrathiophene (DFH-4T).

Table 1 shows that the ionization potential of the new compound 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) appears close to that of DFH-4T but the electron affinity is likely 0.3 eV higher. Consequently, the energy-gap results smaller.

10

Table 1

Oligomer	$\lambda_{\text{max}}^{\text{a}}$ [nm]	$\lambda_{\text{PL}}^{\text{a,b}}$ [nm]	$E^{\circ}_{\text{ox}}$ / V vs. SCE	$E^{\circ}_{\text{red}}$ / V vs. SCE	HOMO [eV]	LUMO [eV]
 <b>12</b>	449	571	1.32	-1.21 <sup>c</sup>	-6.0 <sup>d</sup>	-3.4 <sup>d</sup>
 <b>T4Hex</b>	401 <sup>e</sup>	463, 495, 527 <sup>f</sup>	0.98	-2.17	-5.5	-2.4
 <b>DFH-4T</b>	398 <sup>g</sup>	458, 489	1.35	-1.53	-6.2 <sup>g</sup>	-3.3 <sup>g</sup>

a) in  $\text{CH}_2\text{Cl}_2$ , b),  $\lambda_{\text{exc}} = 449 \text{ nm}$ , c) vs SCE a 200 mV/sin  $\text{CH}_2\text{Cl}_2$ , 0.1 mol  $\text{L}^{-1}$   $(\text{C}_4\text{H}_9)_4\text{NClO}_4$ , d)  $E_{\text{HOMO}} = e (4.68 - E^{\circ}_{\text{ox}})$ ;  $E_{\text{LUMO}} = e (4.68 - E^{\circ}_{\text{red}})$ , e) in toluene, f) shoulder, from ref. Melucci et al, *Chem.Phys.Chem.* 2007, 8, 2621, g) from A.

15 Facchetti, M. Mushrush, H.E. Katz, T.J. Marks *Adv. Mat.* 15 (2003) 35-38.

#### Example 11: Registration of thermal properties.

The thermal behavior of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) was investigated by combining both differential scanning calorimetry (DSC) analysis and hot stage polarized microscopy (POM).

Differential scanning calorimetry (DSC) analysis was performed by using a Thass

DSC-XP-10 instrument under atmospheric conditions.

Hot stage polarized microscopy (POM) was performed by using a Nikon Eclipse 80i optical microscope was used for optical measurements. The images were recorded with a digital color camera Nikon Coolpix 5400. Glass substrate were furnished by Knittel gläser and were washed with Acetone spectroscopic grade before use. Powder samples were sandwiched between two untreated glass plates.

The DSC thermogram was recorded at 10°C/min under ambient conditions and is shown in figure 2. It shows a first endothermic peak at T= 187°C (10.2 J/g, second heating) and a second one corresponding to the melting, located at 280 °C (25.6 J/g).

10 The cooling run (not shown here), showed a single transition corresponding to the crystallization located at 272 °C (-21.4 J/g ).

POM analysis of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) is shown in figure 3. In particular, fig. 3(a) shows that the optical texture of the compound in form of crystalline needles at RT; fig 3(b) shows transition to an LC phase between 198-280°C ; fig 3(c) shows mosaic texture at 280 °C; fig 3(d) shows nematic droplets between 290°C and 295 °C before melting to isotropic phase; fig 3(e) shows crystalline domains growing from the melt; fig. 3(f) shows crystalline phase at 260°C on cooling to RT. The image of the micrographs is size 800µm x 800µm.

20 Therefore, POM analysis of compound 12 according to the invention shows a marked increase in birefringence and fluidity in the range 198°C- 280°C (FIG. 3b), but a mesophase texture can be seen immediately before the melting to isotropic liquid at 295 °C. In fact, a mosaic texture (Fig. 3c) which evolves into nematic droplets (FIG. 3d) can be seen in the range 280-290°C. On cooling the melt, nucleation occurred at about 25 270 °C across the phase transition (FIG. 3e), and leads to crystalline domains that persist to room temperature (FIG. 3f). In thiophene oligomers melt-quenching have already proven to be a powerful method to enhance the molecular order of solution processed films and to promote charge transport in OFET.

Example 12 Registration of single crystal structure

30 For single crystal analysis of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) (compound 12), the X-ray intensity data were measured

on a Bruker SMART Apex II CCD area detector diffractometer. Cell dimensions and the orientation matrix were initially determined from a least-squares refinement on reflections measured in three sets of 20 exposures, collected in three different  $\omega$  regions, and eventually refined against all data. For all crystals, a full sphere of reciprocal space  
5 was scanned by 0.3 °  $\omega$  steps. The software SMART was used for collecting frames of data, indexing reflections and determination of lattice parameters. The collected frames were then processed for integration by the SAINT program, and an empirical absorption correction was applied using SADABS. The structures were solved by direct methods  
10 (SIR 97) and subsequent Fourier syntheses and refined by full-matrix least-squares on  $F^2$  (SHELXTL), using anisotropic thermal parameters for all non-hydrogen atoms. The hydrogen atoms bound to carbons were located in the Fourier maps, added in calculated positions, included in the final stage of refinement with isotropic thermal parameters,  $U(H) = 1.2 U_{eq}(C)$  [ $U(H) = 1.5 U_{eq}(C\text{-Me})$ ], and allowed to ride on their carrier atoms.

The molecular structure of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione), (compound 12) shown in fig. 4a illustrates that the molecule lies on a crystallographic inversion center located at the midpoint of the bond between the two thiophene units. The molecular backbone is almost planar being the two inner thiophene rings strictly coplanar and the dihedral angles between the thiophene and the thiophene-diimide units 4.4(5)°. In fig. 4b and fig. 4c, the crystal  
15 packing of compound 12 shows that the molecules adopt a slipped  $\pi$ - $\pi$  stacking packing mode (interplanar distance ca. 3.51 Å, sliding along the long molecular axis 3.32 Å) instead of the herringbone structure more common for oligothiophenes. Moreover the  
20 molecules of adjacent  $\pi$ - $\pi$  stacks are engaged in supramolecular 1D networks running across the bc plane formed through two intermolecular C-H...O H bonds (H11B...O1 2.54 Å, C11...O1 3.48(1) Å, C11-H11B...O1 162°) in which two oxygen atoms in anti  
25 position (one for each fused ring) interact with one hydrogen atom of the carbon directly attached to the nitrogen of the diimide unit of two different molecules. This molecular arrangement is completed by intermolecular contacts involving the sulfur atoms of the fused thiophene diimide rings (S...S contacts 3.73 Å, sum of the sulfur van der Waals  
30 radii 3.7 Å) of neighbour molecules that do not participate to the C-H...O interactions. The same sulfur atoms are also engaged in weak C-H...S interactions (C-H...S, H...S

3.03 Å) with the inner hydrogens of the thiophene rings.

Example 13: Registration of Atomic Force Microscopy Images of thin films of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)

Semiconductor thin films were fabricated by solution cast as well as vacuum sublimation of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione). Thin films for surface morphology characterization has been grown by vacuum sublimation in a home-made vacuum chamber, with a deposition rate of 0.1 Å/s, at a base pressure of 10<sup>-6</sup> mbar. The films were formed on glass/ITO/PMMA (450 nm) supports. In particular, three films of 2nm, 10nm and 20 nm respectively were formed and the film morphologies investigated by means a NT-MDT Solver Pro AFM atomic force microscope in tapping mode and X-ray diffraction. The obtained results are shown in Fig. 5 a), b) and c) respectively. As shown in Fig. 5 a-c, the films obtained by vacuum sublimation shows a layer by layer mechanism of growth, that is maintained also for high values of the film thickness, i.e. of 20 nm, see FIG. 5 c. From the atomic force microscope (AFM) characterization, it may be concluded that the film surface morphology is highly bidimensional (RMS= 3 nm) for all the film thicknesses relevant in FET devices applications. Such a flat and smooth film surface can guarantee a good organic/organic growth compatibility with a possible top layer and, for this reason, can be particularly suitable for the vertical heterojunction approach in realizing OLET structures.

Example 14: Registration of XRD Patterns of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione)

X-ray diffraction (XRD) patterns of thin films and powder of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione), (compound 12) were carried out by using a PANalytical X'PertPro diffractometer equipped with a fast solid state X'Celerator detector and a copper target ( $\lambda = 0.15418$  nm). Data were acquired in the 3-40° 2θ interval, by collecting 100 sec at each 0.05° step. *In situ* X-ray diffraction analysis of a thin film submitted to a temperature scan was also performed by using an Anton Paar TTK-450 sample stage. Few drops ( $\approx 200\mu\text{l}$ ) of a  $\text{CH}_2\text{Cl}_2$  solution (2mg/ml) of compound 12 were cast directly on the metallic sample holder at RT. After 1h the temperature was increased at 10°C/min and the data collection was

performed at fixed temperature (RT, 100°, 200°, 250°, 285°C) counting 25 sec each 0.05° step in the range 3-8°2θ in order to test the presence of the small angle reflections. Then the sample was cooled at 25°C/min. up to RT and then scanned again (100sec/step).

5

XRD patterns of a) a powder sample, b) a cast film (100 nm), c) cast-melt-quenched film (100 nm), d) a vacuum sublimed film (20 nm) of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) were recorded, and are displayed in fig. 6.

10 Several well resolved diffraction peaks are shown, confirming that an important degree of crystallinity has been obtained. The two peaks at 3.59 and 7.17° (2θ) are the most intense and correspond to the first and second order of a periodicity of 2.46 nm. Both are present either in powder or in film samples, suggesting they are directly connected with one important parameter of the structure. The film cast from a CH<sub>2</sub>Cl<sub>2</sub> 15 solution shows overall the same reflections of the powder sample, that means the presence of the same phase and a random orientation of the crystal domains in the film. After the film melting at 285°C and rapid cooling at RT, the XRD pattern of the film changes completely. At a glance only the two peaks in the small angle region are appreciable, but at high magnification others reflections due to higher order periodicity 20 of the 24.6 nm distance, up to the 10th, are found. Being the molecular length about 2.8 nm and the projection on its main plane is 2.6 nm, the period of 2.46 nm, measured from the XRD pattern of film samples, suggests an arrangement of the molecules close to a vertical position respect to the substrate as roughly sketched in Fig. 6e.

25 Crystal data and structure refinement of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) (compound 12) are summarized as follows:

	Compound	12
	Formula	C <sub>28</sub> H <sub>24</sub> N <sub>2</sub> O <sub>4</sub> S <sub>4</sub>
	M	580.73
30	T, K	293(2)
	Crystal symmetry:	Triclinic

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	Space group	P-1
	<i>a</i> , Å	4.841(4)
	<i>b</i> , Å	11.278(7)
	<i>c</i> , Å	12.907(9)
5	$\alpha$ , °	71.880(9)
	$\beta$ , °	86.80(1)
	$\gamma$ , °	86.93(1)
	<i>V</i> , Å <sup>3</sup>	668.2(8)
	<i>Z</i>	1
10	D <sub>c</sub> , Mg m <sup>-3</sup>	1.443
	$\mu$ (Mo-K <sub>α</sub> ), mm <sup>-1</sup>	0.394
	F(000)	302
	Crystal size, mm	0.50 x 0.02 x 0.01
	$\theta$ limits, °	1.66-24.00
15	Reflections collected	5269
	Unique obs. reflections [Fo > 4σ(Fo)]	2053
	Goodness-of-fit-on F <sup>2</sup>	0.937
	R <sub>1</sub> (F)a [Fo > 4σ (Fo)]	0.0956
	wR <sub>2</sub> (F <sup>2</sup> ) <sup>b</sup>	0.2337
20	Largest diff. peak and hole, e. Å <sup>-3</sup>	-0.448 and 1.228

Example 15: Fabrication of an organic thin film transistor

An organic thin film transistor (OTFT) was fabricated in bottom gate-top contact geometry. The ITO substrate clening procedure used consist of two sonication cycles, in acetone first and 2-isopropanol then, for 10 minutes each. The 450 nm thick dielectric layer of PMMA has been grown by spin-coating on top of the clean ITO substrate (relative electric permittivity  $\epsilon = 3.6$  at 100 Hz). The PMMA film was then thermally annealed in a glove box at 120°C (around 10°C above the glass transition temperature for PMMA) for 15 hours under inert atmosphere. The 30 nm thick layer of 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione) has been grown by

vacuum sublimation in a home-made vacuum chamber, with a deposition rate of 0.1 Å/s, at a base pressure of  $10^{-6}$  mbar. Gold source-drain contacts are then deposited on top of the organic film, properly masked to form a 70 µm length and a 15 mm width channel. The substrate temperature during the film deposition has been kept at room 5 temperature (RT).

The electrical measurements are performed by means of a Suss PM5 professional probe station connected with an Agilent B1500A parametric analyzer located inside a dry inert glove box. The probe station has been equipped with a Hamamatsu S1337 photodiode with an active area of 1 cm<sup>2</sup>, located under the OTFT channel, in order to 10 collect the electroluminescence originating from the working device. Further device features were:

$$C_{PMMA} = 7.08 \text{ nF/cm}^2$$

The electrical response of the fabricated OTFT has been measured in nitrogen controlled atmosphere, using a commercial probe station Suss PM5 professional probe 15 station equipped with a photodiode in order to collect possible electroluminescence originating from the working device. The probe station is integrated with a B1500 Agilent parametric analyzer. The obtained results consist in the graphs reported in Fig. 7.

Electrical characterization of the realized OTFT shows ambipolar behavior. The 20 electron contribution is the most relevant as the high value ( $0.053 \text{ cm}^2/\text{Vs}$ ,  $V_T^N = 60 \text{ V}$ ) of the N-type mobility demonstrates, as it can be seen in Fig. 7 a) showing locus curve N type. A three-order-of-magnitude lower hole mobility ( $\mu_P = 6.4 \times 10^{-5} \text{ cm}^2/\text{V} \times \text{s}$ ,  $V_T^P = -71 \text{ V}$ ) has been calculated from the P-type locus curve reported in FIG. 7b. In spite of 25 the low value of the hole current contribution, this feature plays a major role in the generation of the electroluminescence signal clearly visible in the Transfer saturation N-type and multiple output N-type curves reported in FIG. 7 c) and d), respectively. The light emission signal of the Transfer curve is peaked in the ambipolar working region of the device, in agreement with the typical behavior reported for single layer ambipolar Organic Light Emitting Transistors (OLET). Moreover, correlated to the presence of 30 environmental light, an increase of the total OTFT flowing current has been detected. In Fig. 7 e) is reported a single output curve collected by switching the measurement

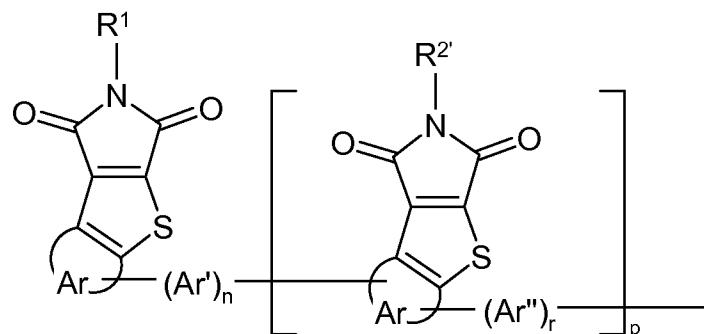
condition from the complete dark, to the presence of a neon lamp. Each step, recognizable in the saturation portion of the curve, is correlated to the light-on measurement condition. This behavior can be described in terms of photocurrent generation. In conclusion, the results obtained from the opto-electronic characterization of single layer OTFTs based on 2,2'-(2,2'-bithiophene-5,5'-diyl)bis(5-butyl-5H-thieno[2,3-c]pyrrole-4,6-dione), make this compound suitable not only for charge transport application in Field Effect configuration, but also for light emitting applications (OLETs) as well as for light sensing (Light Sensing Field Effect Transistors) or organic photovoltaic applications.

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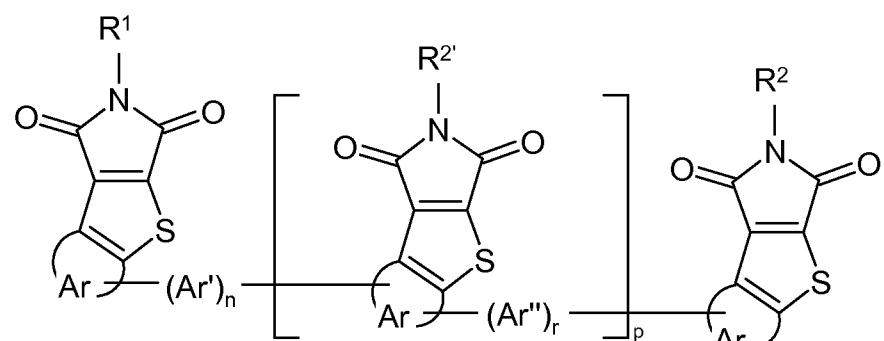
## CLAIMS

1. A compound having formula selected in the group consisting of formula (I), formula (II), formula (III) and formula (IV):

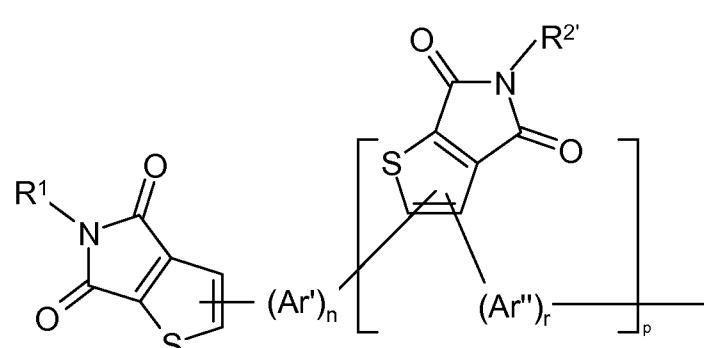
5



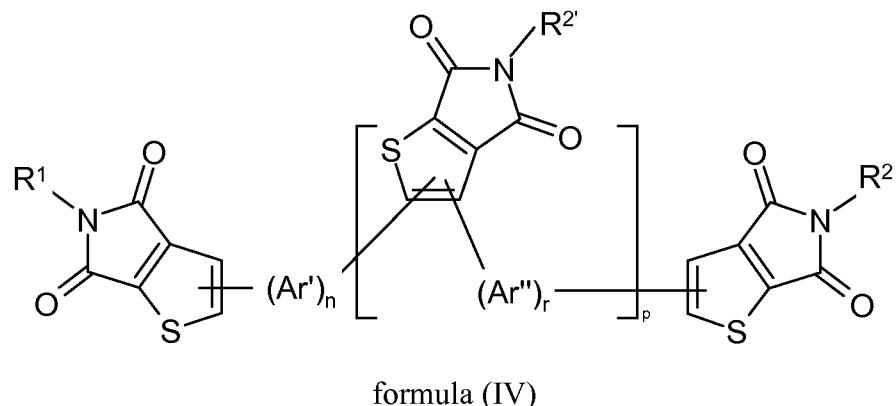
formula (I)



10 formula (II)



formula (III)



5 wherein:

10  $R^1$ ,  $R^2$ ,  $R^{2'}$  independently of each other, are selected in the group consisting of hydrogen, C<sub>1</sub>-C<sub>40</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched heteroalkyl groups, C<sub>3</sub>-C<sub>40</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>40</sub> linear or branched nitrile groups;

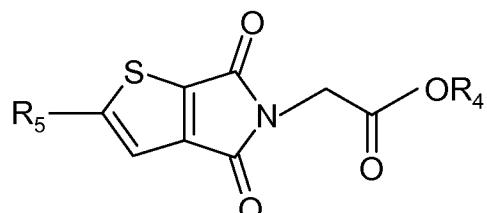
15 Ar is selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

20  $Ar'$ ,  $Ar''$ , independently of each other, are selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

$n$ ,  $r$ , independently of each other, are integers between 1 and 50; and

$p$  is an integer between 0 and 5;

25 with the exception of compounds of formula A:

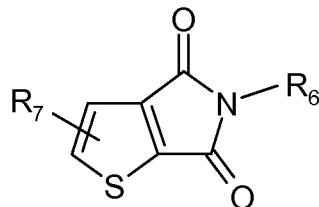


formula A

- 37 -

wherein  $R_4$  is selected in the group consisting of  $C_1$ - $C_4$  alkyls; and  $R_5$  is selected in the group consisting of monocyclic aryl groups and substituted monocyclic aryl groups;

and with the exception of compounds of formula B:



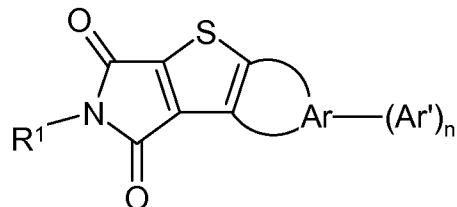
formula B

wherein  $R_6$  is selected in the group consisting of isopropyl, cyclopropyl and terbutyl groups and  $R_7$  is selected in the group consisting of phenyl, 2-fluorophenyl, 3-fluorophenyl, 4-fluorophenyl, 2-chlorophenyl, 3-chlorophenyl, 4-chlorophenyl, 2-methylphenyl, 3-methylphenyl, 4-methylphenyl, 2-trifluoromethylphenyl, 3-trifluormethylphenyl, 4-trifluormethylphenyl, 2-methoxyphenyl, 3-methoxyphenyl, 4-methoxyphenyl, 2,4-dichlorophenyl, 2,4,6-trimethylphenyl, 2-thienyl, 3-thienyl, 2-pyridyl, 3-pyridyl, 4-pyridyl.

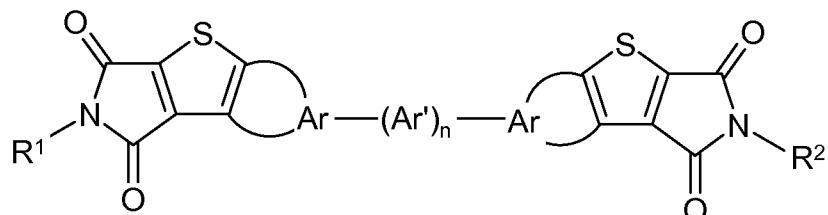
2. A compound according to claim 1, wherein when  $p$  is 0,  $n$  is between 2 and

15 50.

3. A compound according to claim 1 or 2, having formula selected in the group consisting of formula (Ia), formula (IIa), formula (IIIa) and formula (IVa)

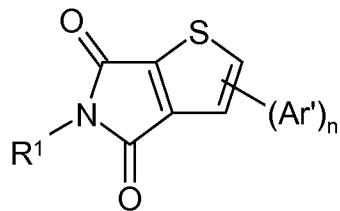


formula (Ia)

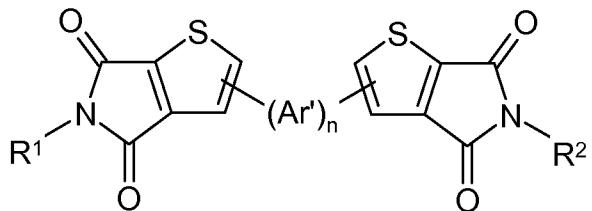


formula (IIa)

- 38 -



formula (IIIa)



formula (IVa)

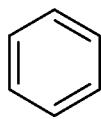
5 wherein:

10  $R^1$ ,  $R^2$ , independently of each other, are selected in the group consisting of hydrogen, C<sub>1</sub>-C<sub>40</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched heteroalkyl groups, C<sub>3</sub>-C<sub>40</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>40</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>40</sub> linear or branched nitrile groups;

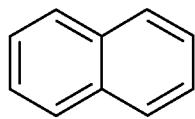
15 Ar is selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl group and polycyclic heteroaryl group;

Ar' is a moiety selected in the group consisting of a monocyclic aryl group, polycyclic aryl group, monocyclic heteroaryl group and polycyclic heteroaryl group.

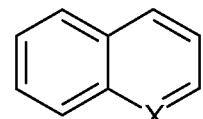
4. A compound according to the previous claim, wherein Ar is selected in the group consisting of the following rings (f), (g), (h), (i), (l), (m), (n), (o), (p):



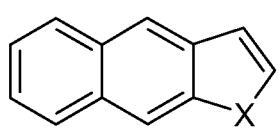
(f)



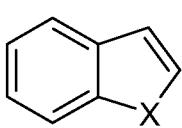
(g)



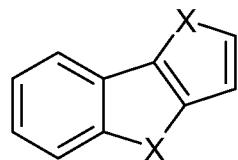
(h)



(i)



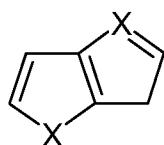
(1)



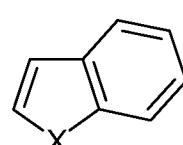
(m)



(n)



(e)



(n)

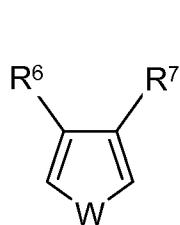
wherein X is selected in the group consisting of S, O, Si, Se, NR<sup>3</sup>,

$R^3$  being selected in the group consisting of  $C_1$ - $C_{12}$  linear or branched alkyl groups,  $C_1$ - $C_{12}$  linear or branched halogenoalkyl groups,  $C_3$ - $C_{12}$  linear or branched cycloalkyl groups,  $C_1$ - $C_{12}$  linear or branched hydroxyalkyl groups,  $C_1$ - $C_{12}$  linear or branched alkoxy groups,  $C_1$ - $C_{12}$  linear or branched alkylcarboxylic groups,  $C_1$ - $C_{12}$  linear or branched alkylcarboxamide groups,  $C_1$ - $C_{12}$  linear or branched alkylsulphonic groups, and  $C_1$ - $C_{12}$  linear or branched nitrile groups.

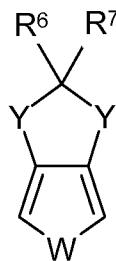
5. A compound according to one of the previous claims, wherein R<sup>1</sup>, R<sup>2</sup>,  
10 independently of each other, are selected in the group consisting of C<sub>1</sub>-C<sub>12</sub> linear or  
branched alkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched heteroalkyl groups, C<sub>3</sub>-C<sub>12</sub> linear or  
branched cycloalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>12</sub>  
linear or branched alkoxy groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxylic groups,  
C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>12</sub> linear or branched  
15 alkylsulphonic groups, and C<sub>1</sub>-C<sub>12</sub> linear or branched nitrile groups.

6. A compound according to one of the previous claims, wherein Ar' is a unit selected in the group consisting of the following units (a), (b), (c):

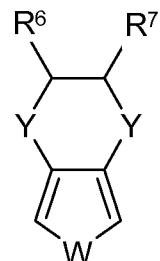
- 40 -



(a)



(b)



(c)

wherein W is selected in the group consisting of S, SO and SO<sub>2</sub>;

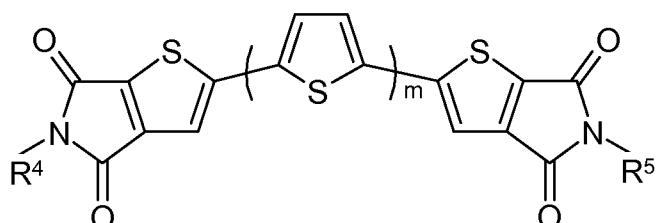
Y is selected in the group consisting of S, O, NR<sup>8</sup>; and

R<sup>6</sup>, R<sup>7</sup>, and R<sup>8</sup> independently of each other, are selected in the group consisting of

5 hydrogen, C<sub>1</sub>-C<sub>12</sub> linear or branched alkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched halogenoalkyl groups, C<sub>3</sub>-C<sub>12</sub> linear or branched cycloalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched hydroxyalkyl groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkoxy groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxylic groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylcarboxamide groups, C<sub>1</sub>-C<sub>12</sub> linear or branched alkylsulphonic groups, and C<sub>1</sub>-C<sub>12</sub> linear or branched

10 nitrile groups..

7. A compound according to claim 1 having the following formula (V):



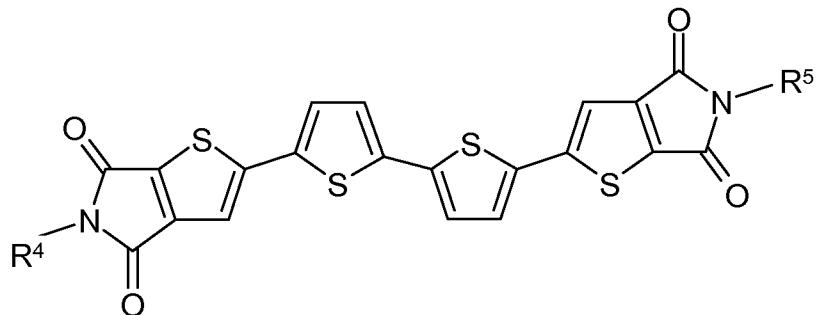
formula (V)

wherein R<sup>4</sup>, R<sup>5</sup>, independently of each other, are selected in the group consisting

15 of C<sub>1</sub>-C<sub>8</sub> linear or branched saturated alkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched fluoroalkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched heteroalkyl groups comprising a heteroatom selected among O, S, N; and

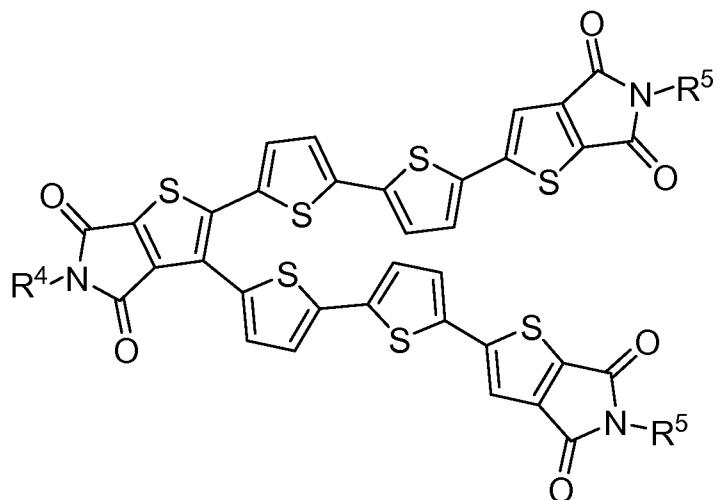
m is an integer between 1 and 30.

8. A compound according to the previous claim, having formula (VI):



formula (VI).

9. A compound according to claim 1 having the following formula (VII):



5

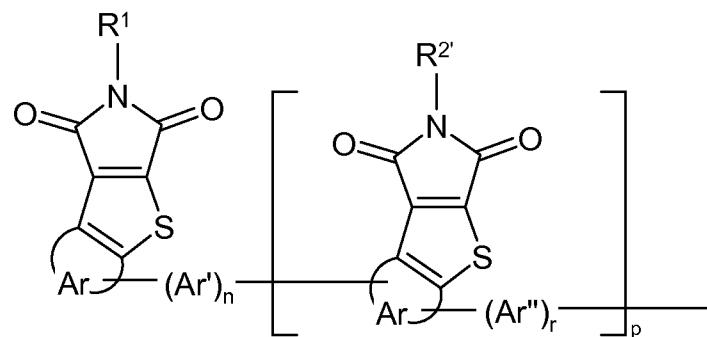
formula (VII)

wherein R<sup>4</sup>, R<sup>5</sup>, independently of each other, are selected in the group consisting of C<sub>1</sub>-C<sub>8</sub> linear or branched saturated alkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched fluoroalkyl groups, C<sub>1</sub>-C<sub>8</sub> linear or branched heteroalkyl groups comprising a heteroatom selected among O, S, N

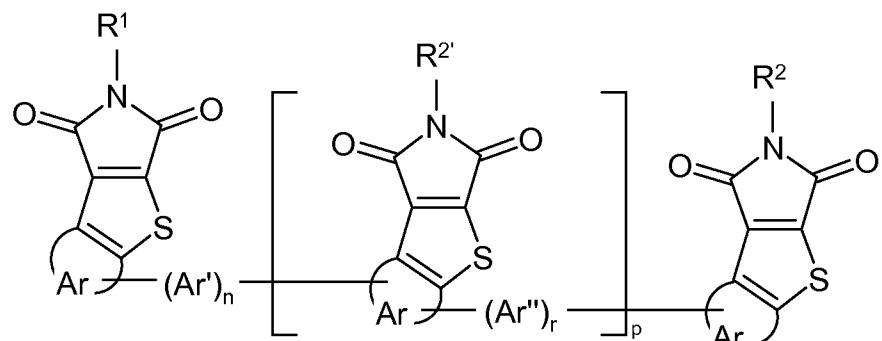
10 10. A process for the preparation of a compound according to one of claims 1 to 9, characterized in that it comprises: subjecting a reaction mixture comprising a reaction medium and an halogenated aromatic halide to: a Stille coupling reaction with an organotin compound; or to a Suzuki coupling reaction with an organoboron compound.

11. Use of a compound having formula selected in the group consisting of 15 formula (I), formula (II), formula (III) and formula (IV):

- 42 -

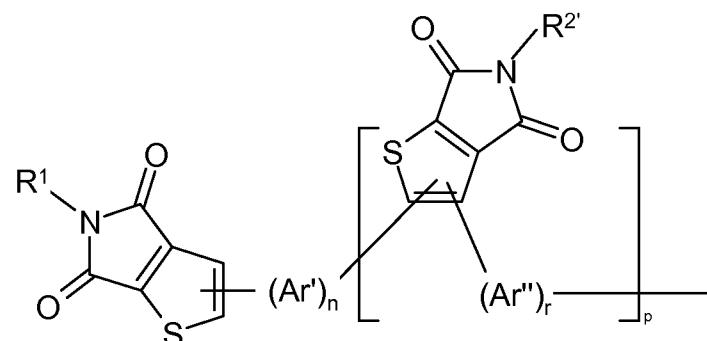


formula (I)



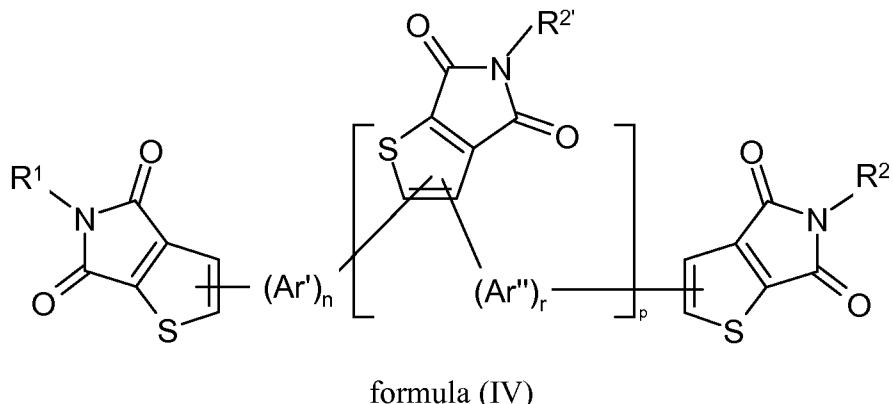
5

formula (II)



formula (III)

10



wherein:

5       $R^1$ ,  $R^2$ ,  $R^{2'}$  independently of each other, are selected in the group consisting of hydrogen,  $C_1$ - $C_{40}$  linear or branched alkyl groups,  $C_1$ - $C_{40}$  linear or branched heteroalkyl groups,  $C_3$ - $C_{40}$  linear or branched cycloalkyl groups,  $C_1$ - $C_{40}$  linear or branched hydroxyalkyl groups,  $C_1$ - $C_{40}$  linear or branched alkoxy groups,  $C_1$ - $C_{40}$  linear or branched alkylcarboxylic groups,  $C_1$ - $C_{40}$  linear or branched alkylcarboxamide groups,  $C_1$ - $C_{40}$  linear or branched alkylsulphonic groups, and  $C_1$ - $C_{40}$  linear or branched nitrile groups;

Ar is selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

15       $Ar'$ ,  $Ar''$ , independently of each other, are selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

    n, r, independently of each other, are integers between 1 and 50; and

    p is an integer between 0 and 5;

    as an organic semiconductor material in an electronic device.

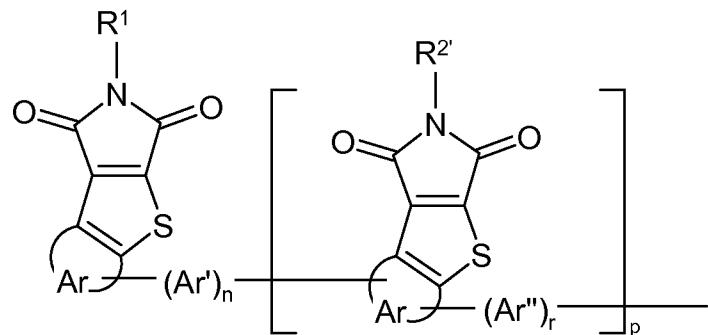
12. Use of a compound according to any of claims 2 to 10 as an organic 20 semiconductor material in an electronic device.

13. Use according to claim 11 or 12, as n-type organic semiconductor material in an electronic device.

14. An electronic device comprising a semiconductor layer in contact with a number of electrodes, wherein the semiconductor layer includes at least one compound 25 having formula selected in the group consisting of formula (I), formula (II), formula

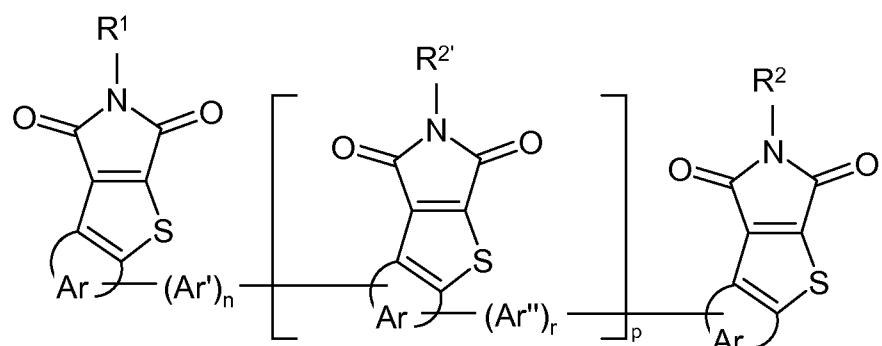
- 44 -

(III) and formula (IV):

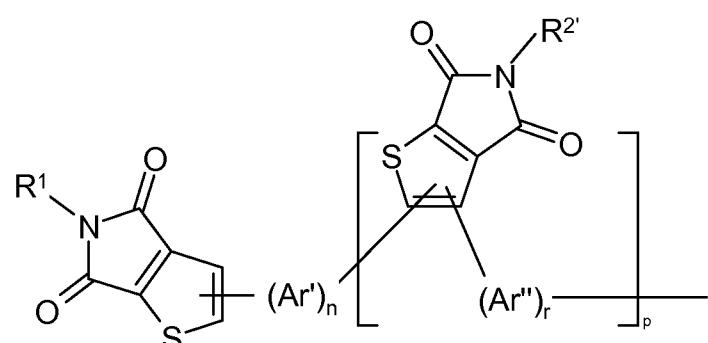


formula (I)

5

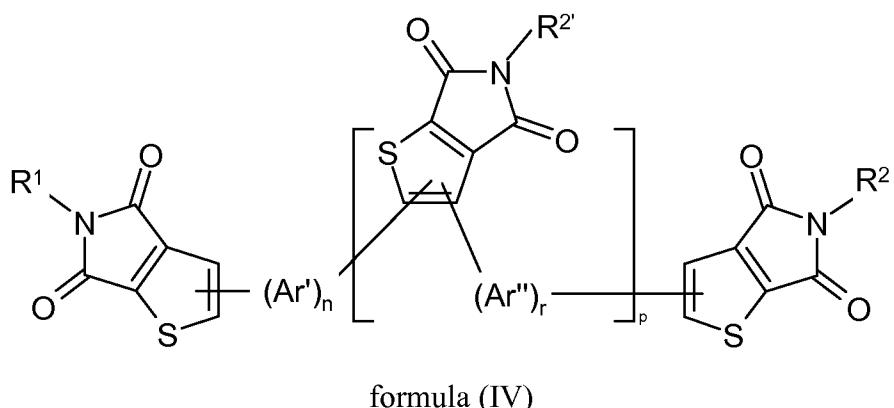


formula (II)



formula (III)

10



wherein:

$R^1$ ,  $R^2$ ,  $R^{2'}$  independently of each other, are selected in the group consisting of  
5 hydrogen,  $C_1$ - $C_{40}$  linear or branched alkyl groups,  $C_1$ - $C_{40}$  linear or branched heteroalkyl  
groups,  $C_3$ - $C_{40}$  linear or branched cycloalkyl groups,  $C_1$ - $C_{40}$  linear or branched  
hydroxyalkyl groups,  $C_1$ - $C_{40}$  linear or branched alkoxy groups,  $C_1$ - $C_{40}$  linear or  
branched alkylcarboxylic groups,  $C_1$ - $C_{40}$  linear or branched alkylcarboxamide groups,  
10  $C_1$ - $C_{40}$  linear or branched alkylsulphonic groups, and  $C_1$ - $C_{40}$  linear or branched nitrile  
groups;

Ar is selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and polycyclic heteroaryl groups;

Ar', Ar'', independently of each other, are selected in the group consisting of monocyclic aryl groups, polycyclic aryl groups, monocyclic heteroaryl groups and 15 polycyclic heteroaryl groups;

*n, r, independently of each other, are integers between 1 and 50; and*

$p$  is an integer between 0 and 5.

15. An electronic device comprising a semiconductor layer in contact with a number of electrodes, wherein the semiconductor layer includes at least one compound according to one of claims 2 to 9.

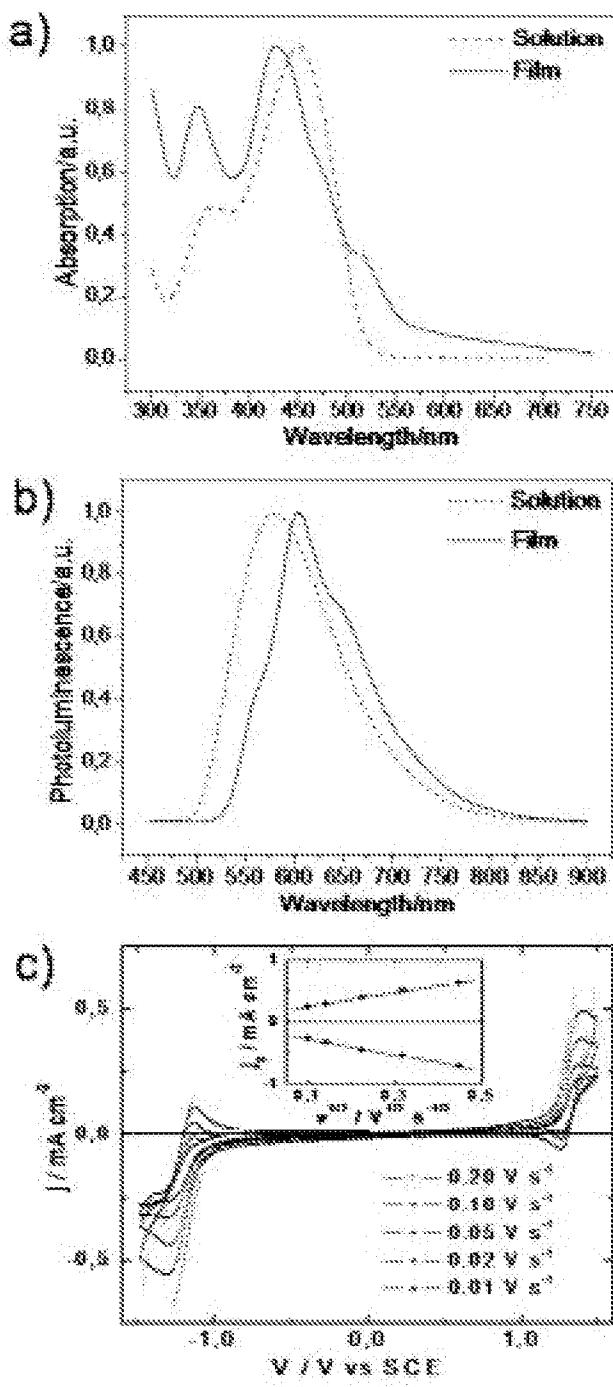


Fig.1

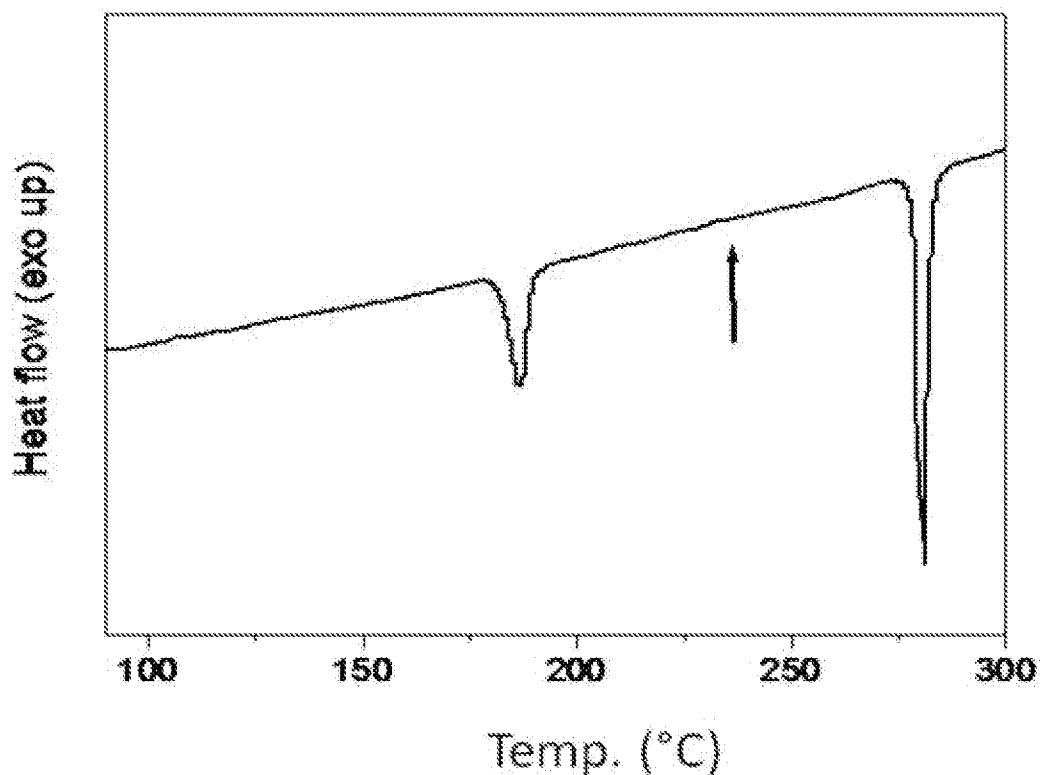


Fig.2

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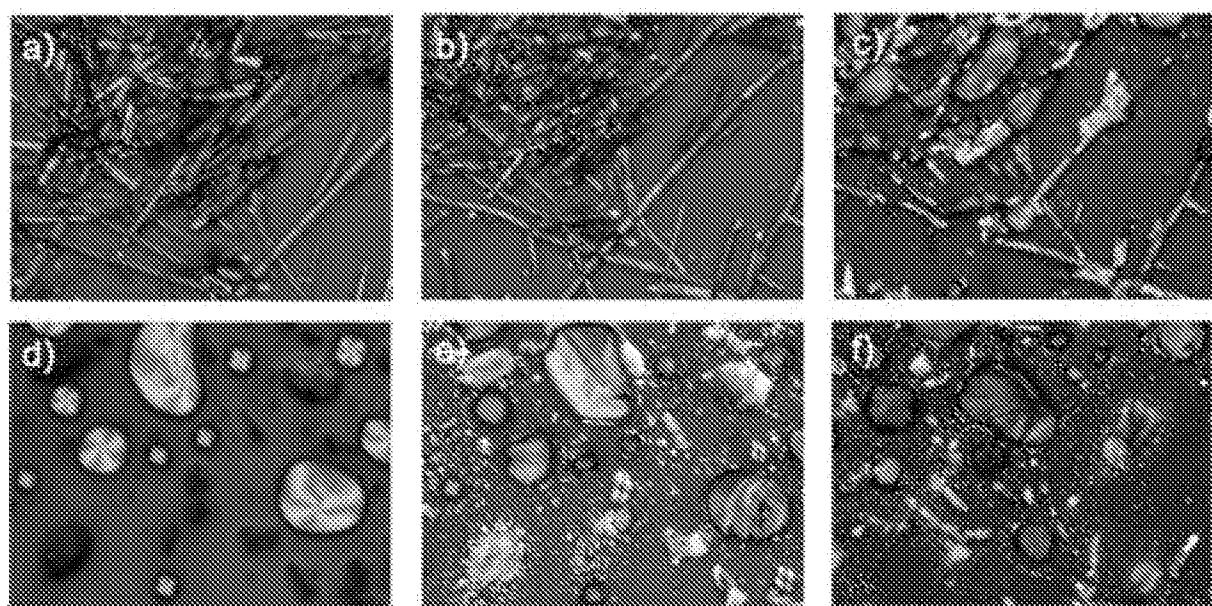


Fig.3

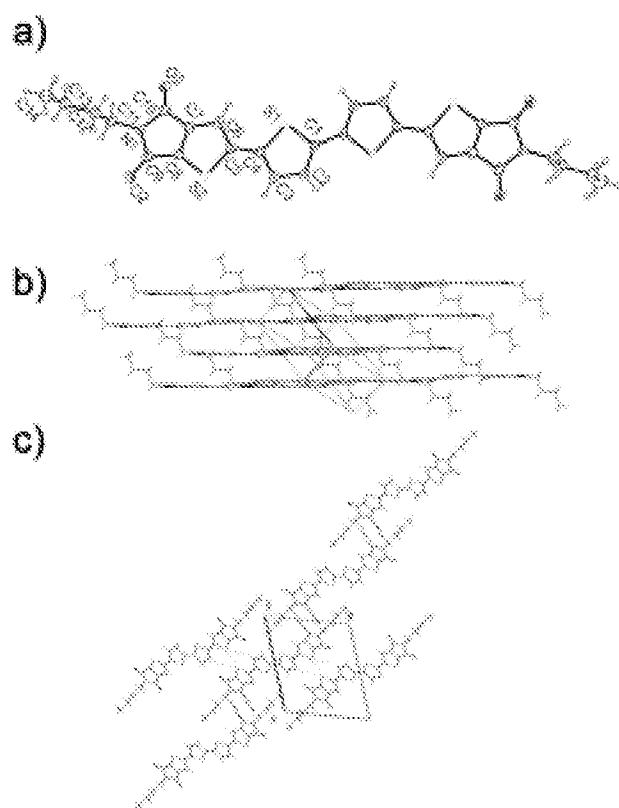
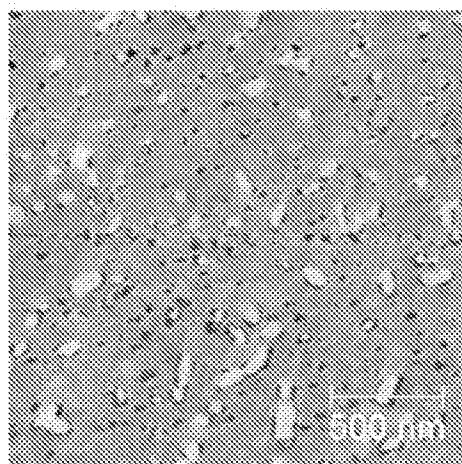


Fig.4

a)



b)

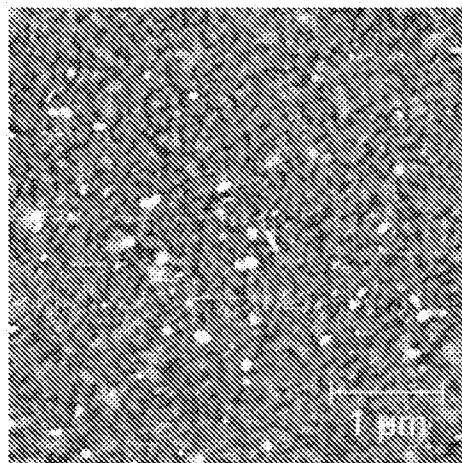
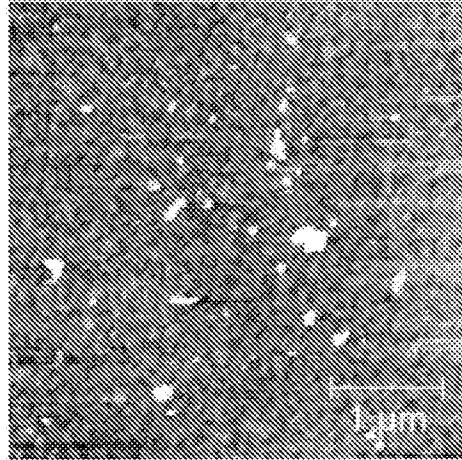


Fig.5

c)



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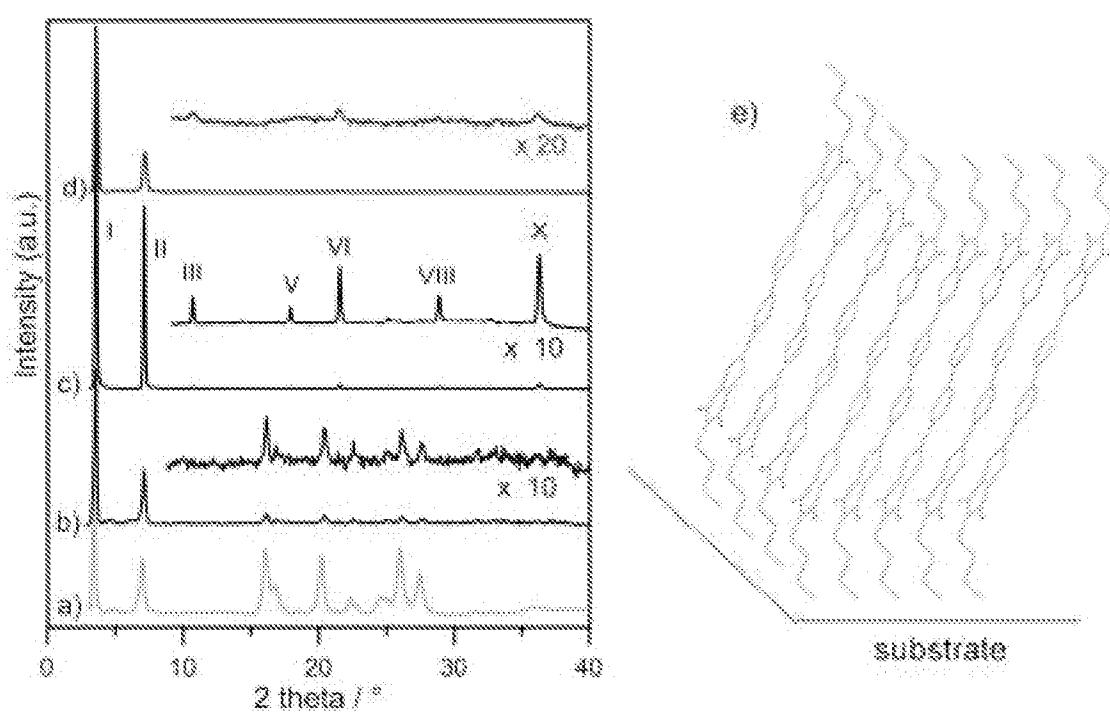


Fig.6

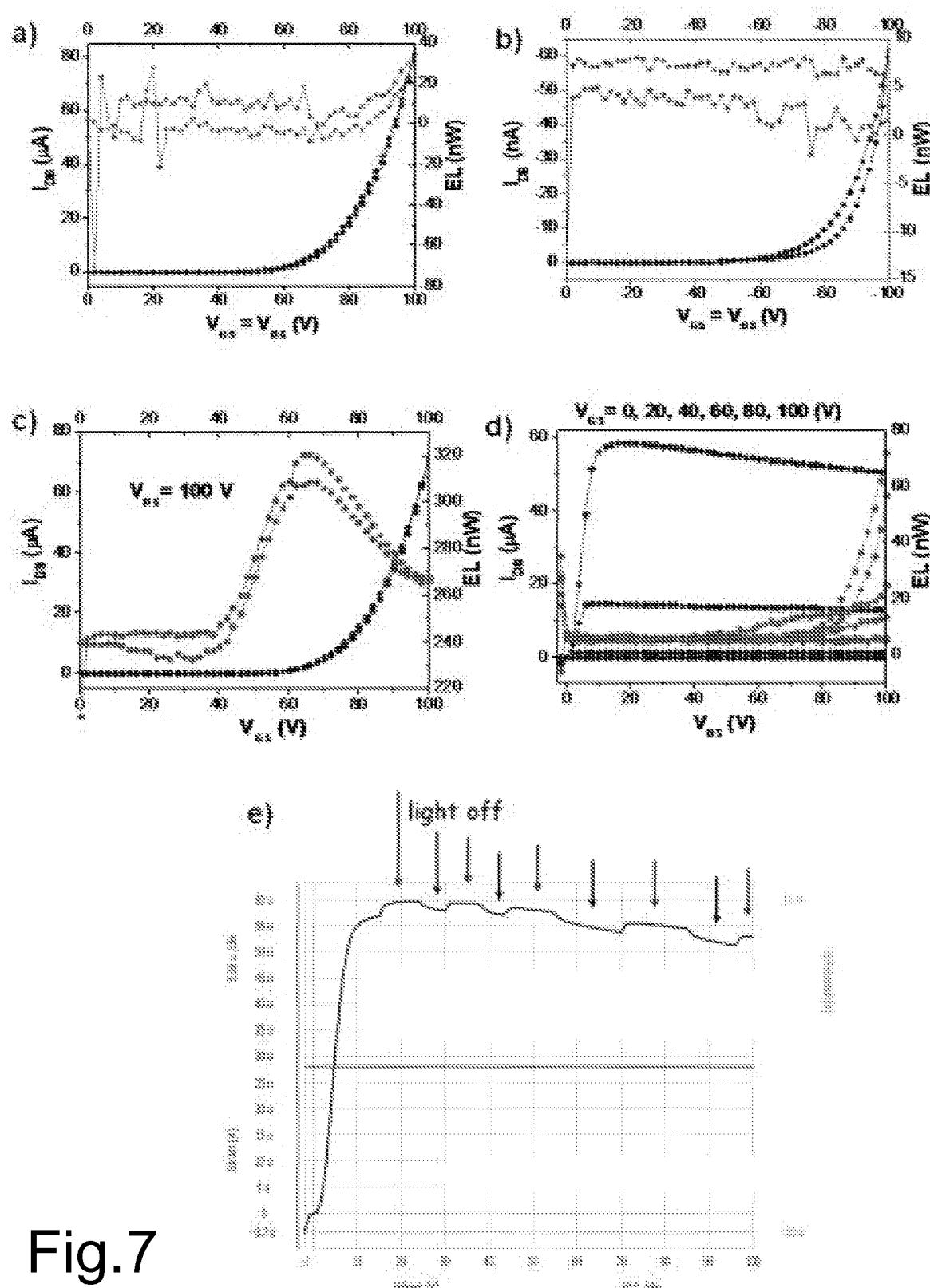


Fig.7

# INTERNATIONAL SEARCH REPORT

International application No  
PCT/IB2012/052503

**A. CLASSIFICATION OF SUBJECT MATTER**  
INV. C07D495/04 C07D495/14 C07D495/22 H01L51/00  
ADD.

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**

Minimum documentation searched (classification system followed by classification symbols)

C07D H01L

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

EPO-Internal, WPI Data, CHEM ABS Data

**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	WO 2006/094292 A2 (FIBROGEN INC [US]; TURTLE ERIC D [US]; FLIPPIN LEE A [US]; AREND MICHA) 8 September 2006 (2006-09-08) page 36 - page 51; example 132 -----	1
A	EP 0 467 206 A2 (BASF AG [DE]) 22 January 1992 (1992-01-22) page 43; example 2.052 -----	1-15
X	DE 19 54 550 A1 (BASF AG) 8 July 1971 (1971-07-08) examples ----- -/-	1

Further documents are listed in the continuation of Box C.

See patent family annex.

\* Special categories of cited documents :

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- "E" earlier application or patent but published on or after the international filing date
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- "O" document referring to an oral disclosure, use, exhibition or other means
- "P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&" document member of the same patent family

Date of the actual completion of the international search	Date of mailing of the international search report
27 June 2012	05/07/2012

Name and mailing address of the ISA/ European Patent Office, P.B. 5818 Patentlaan 2 NL - 2280 HV Rijswijk Tel. (+31-70) 340-2040, Fax: (+31-70) 340-3016	Authorized officer  Fazzi, Raffaella
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## INTERNATIONAL SEARCH REPORT

International application No
PCT/IB2012/052503

## C(Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT

Category <sup>*</sup>	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	RONOVA INGA A ET AL: "The effect of the conformational rigidity on the initial decomposition temperature of some heterocyclic polyimides", HIGH PERFORMANCE POLYMERS, INSTITUTE OF PHYSICS PUBLISHING, BRISTOL, GB, vol. 14, no. 2, 1 January 2002 (2002-01-01), pages 195-208, XP008126385, ISSN: 0954-0083 page 197 - page 202; examples 1-2; table 1 -----	1,2
X	GAINA C ET AL: "Polyimides containing 1,4-dithiine units and their corresponding thiophene 2,3,4,5 tetracarboxylimide units", HIGH PERFORMANCE POLYMERS, INSTITUTE OF PHYSICS PUBLISHING, BRISTOL, GB, vol. 11, no. 2, 1 June 1999 (1999-06-01), pages 185-195, XP001537372, ISSN: 0954-0083, DOI: 10.1088/0954-0083/11/2/003 page 188; examples 6,8 -----	1
Y	WO 2008/127029 A1 (LG CHEMICAL LTD [KR]; MOON JAE-MIN [KR]; CHOI HYEON [KR]; LEE JAE-MIN) 23 October 2008 (2008-10-23) claims; examples -----	1-11
Y	WEI HONG ET AL.: "Linera Fused Dithieno[2,3-b:3'2'-d]-thiophene Diimides", ORGANIC LETTERS, vol. 13, no. 6, 18 March 2011 (2011-03-18) , pages 1410-1413, XP002661168, the whole document -----	1-11

# INTERNATIONAL SEARCH REPORT

Information on patent family members

International application No

PCT/IB2012/052503

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